

ADVANCED PHOTON SOURCE

LEUTL/FEL Project

- Joint Project Between
 - Accelerator Systems Division
 - Experimental Facilities Division
- Actively Involved Groups

Accelerator Systems Division	Experimental Facilities Division
Controls	Insertion Devices
Diagnostics	
Mechanical	
Operations	
Operations Analysis	
Accelerator Physics	
Power Supplies	
RF	
Survey	
Vacuum	

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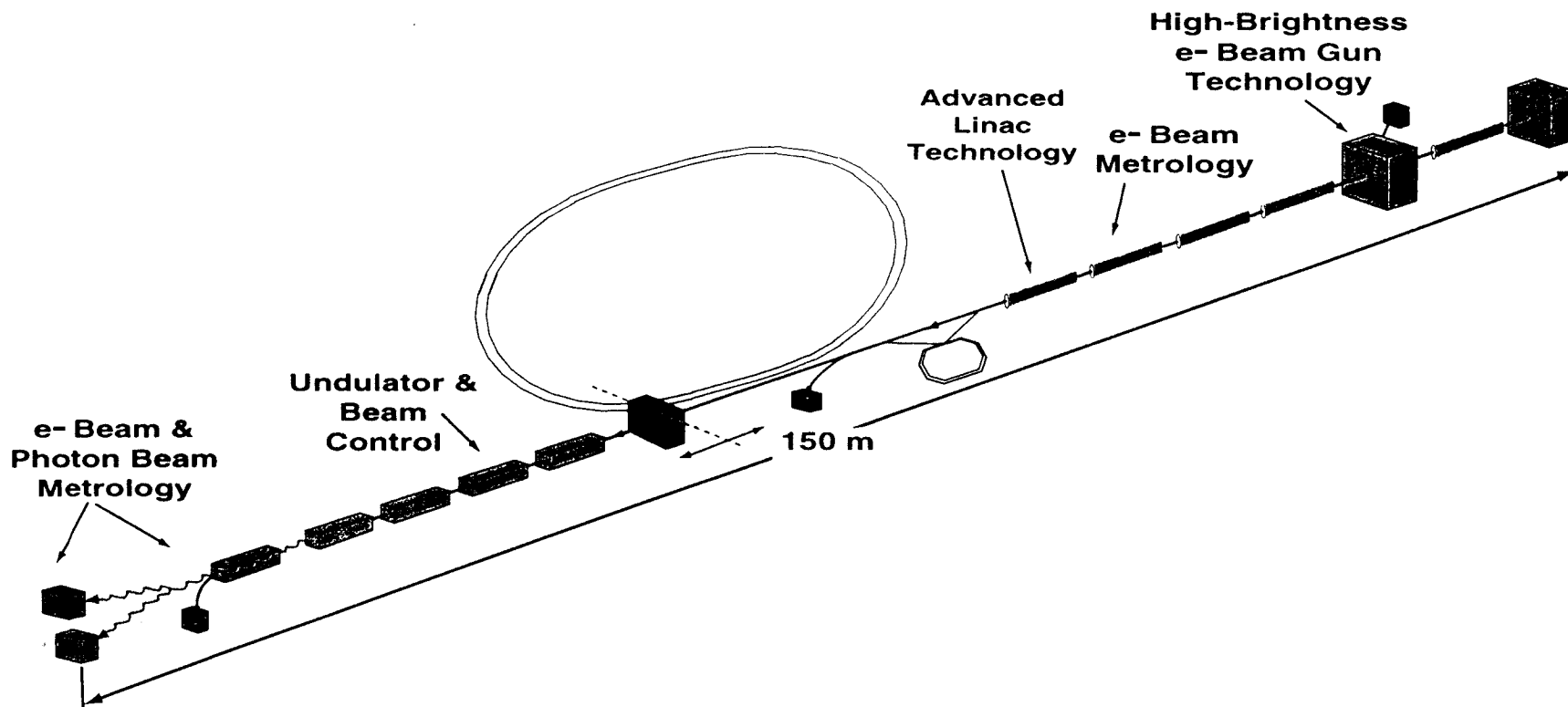
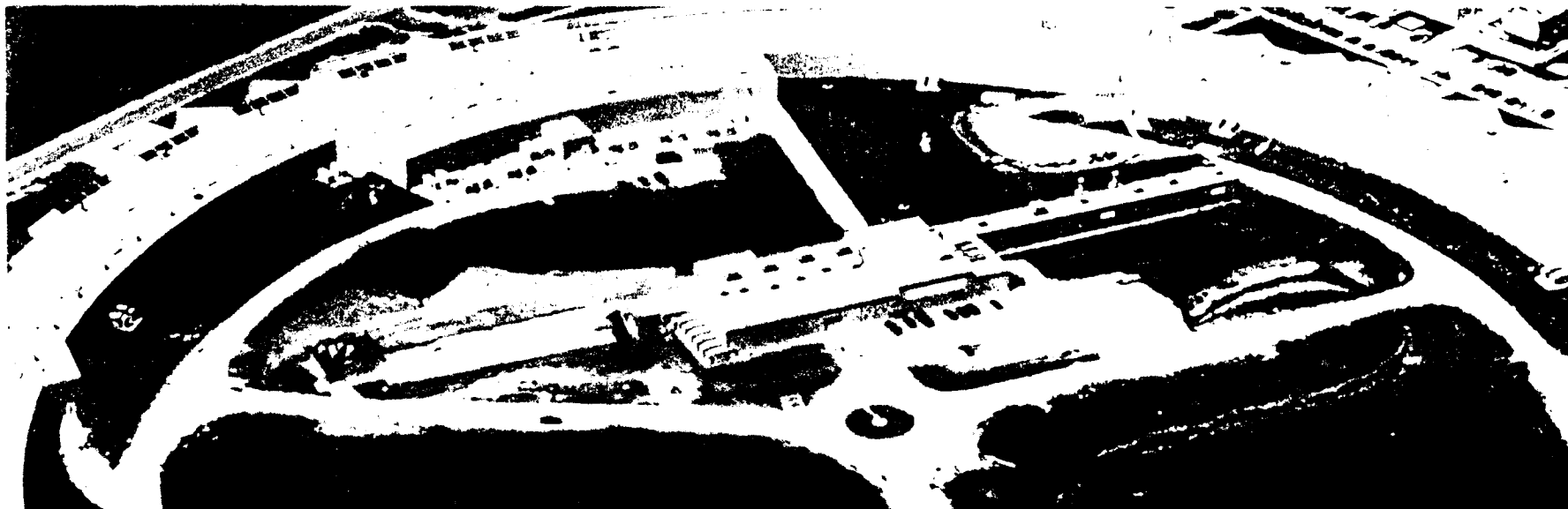
LEUTL/FEL Project

- **Project Leadership**
 - S. Milton (ASD)
 - E. Gluskin (XFD)

- **The Hard Working Commissioning Team**
 - N. Arnold (ASD)
 - S. Biedron (ASD)
 - M. Borland (ASD)
 - P. Den Hartog (XFD)
 - K. Harkay (ASD)
 - J. Lewellen (ASD)
 - A. Lumpkin (ASD)
 - E. Moog (XFD)
 - A. Nassiri (ASD)
 - V. Sajaev (ASD)
 - N. Sereno (ASD)
 - G. Travish (ASD)

- **Others**
 - BNL Accelerator Test Facility
 - ♦ PC RF Gun
 - ♦ XJ Wang

ADVANCED PHOTON SOURCE LOW-ENERGY UNDULATOR TEST LINE



ADVANCED PHOTON SOURCE

APS Low-Energy Undulator Test Line (LEUTL)

R&D program for UV FEL

- Goal is to study the process of self-amplified spontaneous emission (SASE)
- Pursue scientific demonstration experiments impossible with existing sources
- Novel beam characteristics (50 -> 500 nm)
 - Pulse duration 1 -> 5 psec @ 10 Hz
 - Peak power of 100 MW (1st harmonic)
 - Time-average power 0.1 W (1st harmonic)
 - Time-average brilliance 10^{20}
 - Peak brilliance 10^{28}
- Schedule is to begin SASE experiments at 530 nm in August '99

ADVANCED PHOTON SOURCE

FEL Operation Requirements

- SASE MODE: Basic Description

Spontaneous emission + bunch irregularities



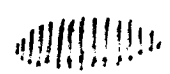
Bunching begins



Field strength increase



Exponential growth of coherent field



electron beam

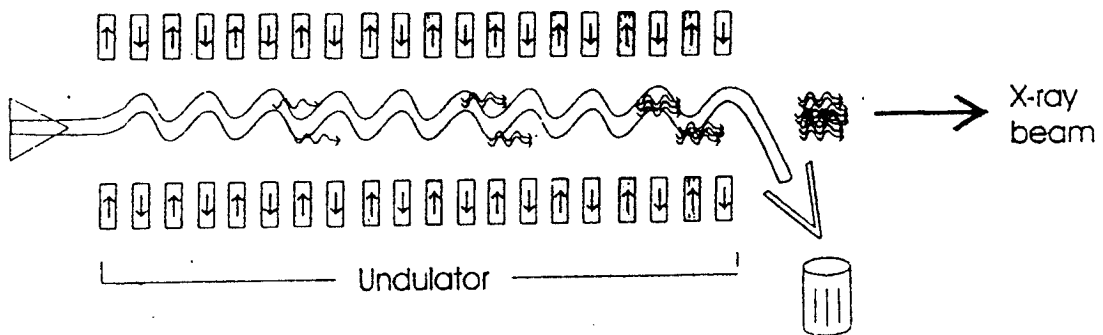
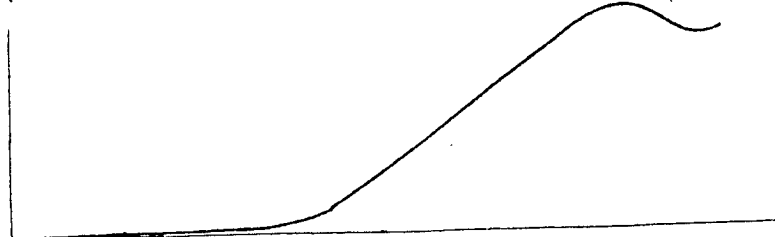


Figure 1.1.1

$\log(\text{radiation power})$



distance

ADVANCED PHOTON SOURCE

- SASE PARAMETERIZATION

- The Pierce Parameter

$$\rho \propto \left[\frac{I_{peak} K^2 \lambda_w^2}{\sigma_{trans}^2 \gamma^3} \right]^{1/3} = \left[\frac{I_{peak}}{\sigma_{trans}^2} \frac{\lambda^2 \gamma K^2}{\left(1 + K^2/2\right)^2} \right]^{1/3}$$

- The Gain Length

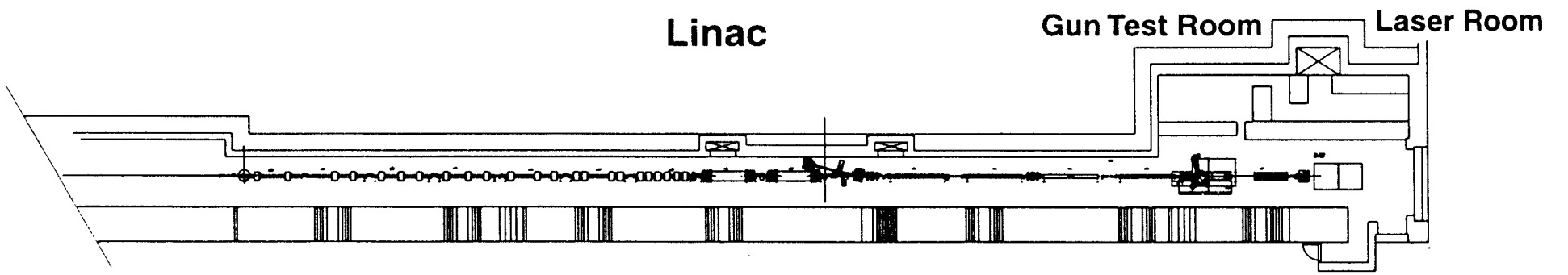
$$L_{gain} = \frac{1}{1 + \eta} L_{gain}^{1-D} = \frac{1}{1 + \eta} \frac{\lambda_w}{4\pi\sqrt{3}\rho}$$

- Efficient Operation

$$\frac{4\pi\epsilon}{\lambda_{light}} \leq 1 \quad \frac{L_{gain}}{L_R} \leq 1 \quad \frac{\sigma_\gamma}{\gamma} \leq \rho$$

- Quickly Summing Up

Make ρ as large as possible without violating conditions for efficient operation.

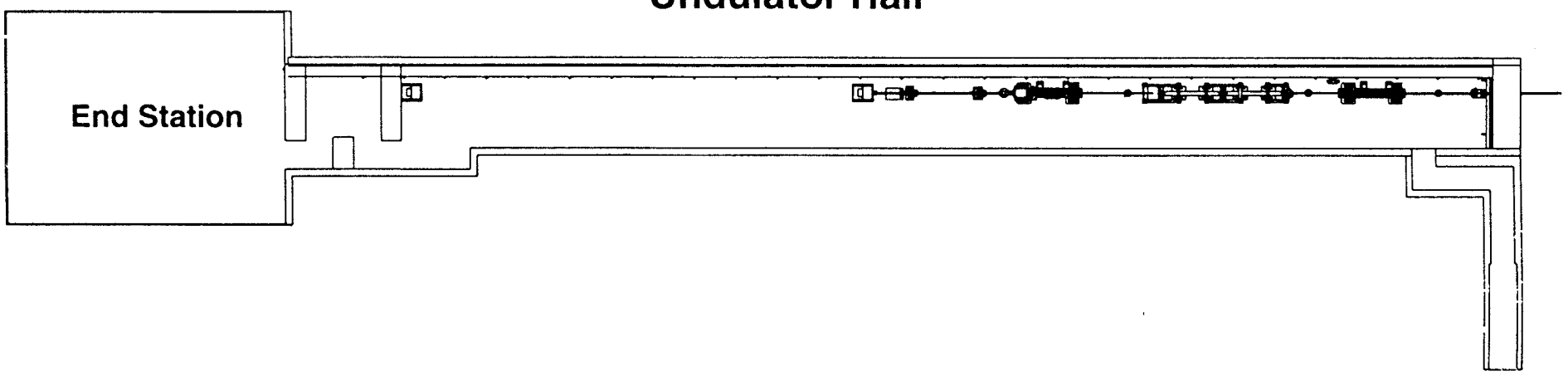


Linac

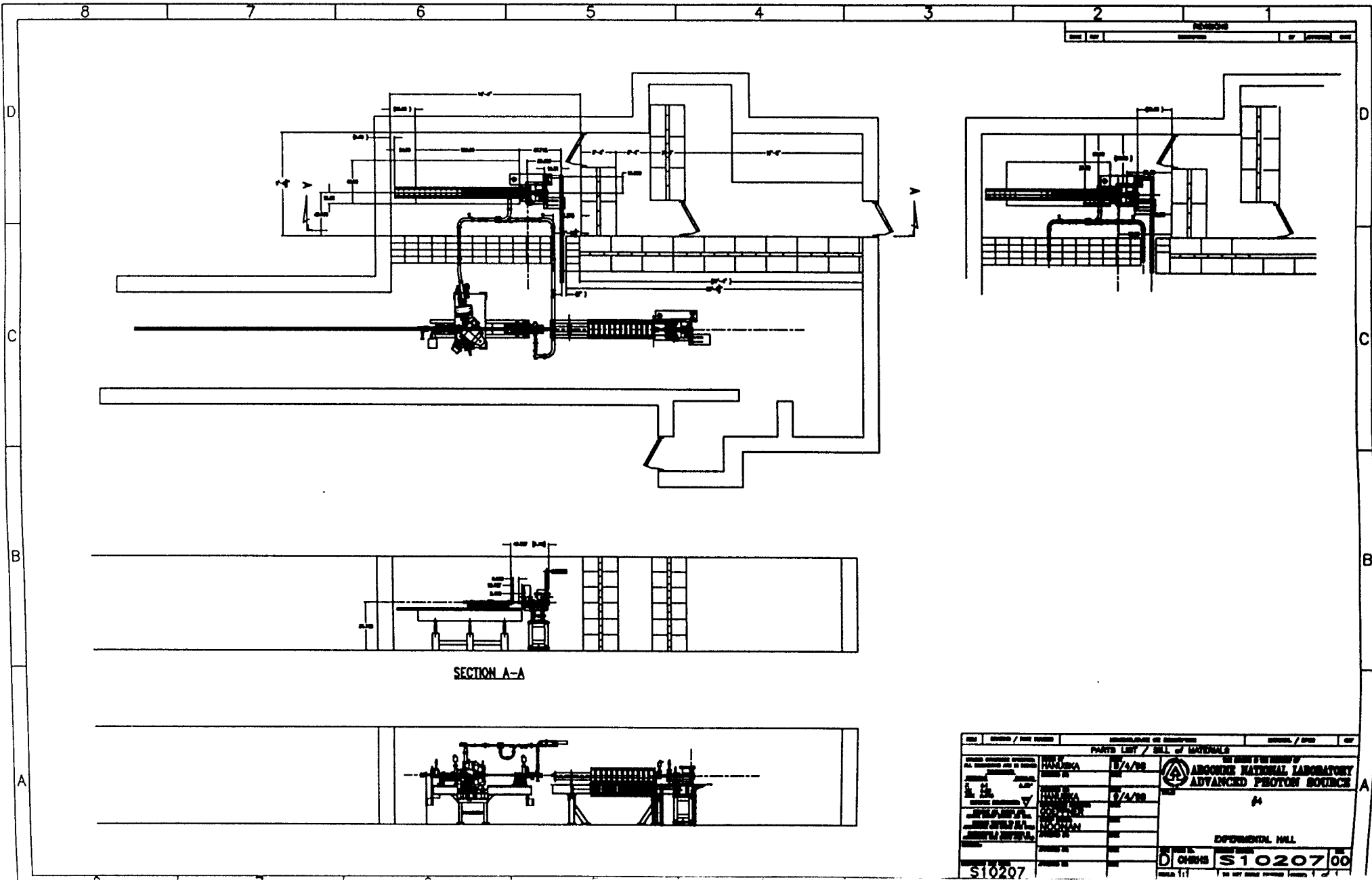
Gun Test Room

Laser Room

Undulator Hall



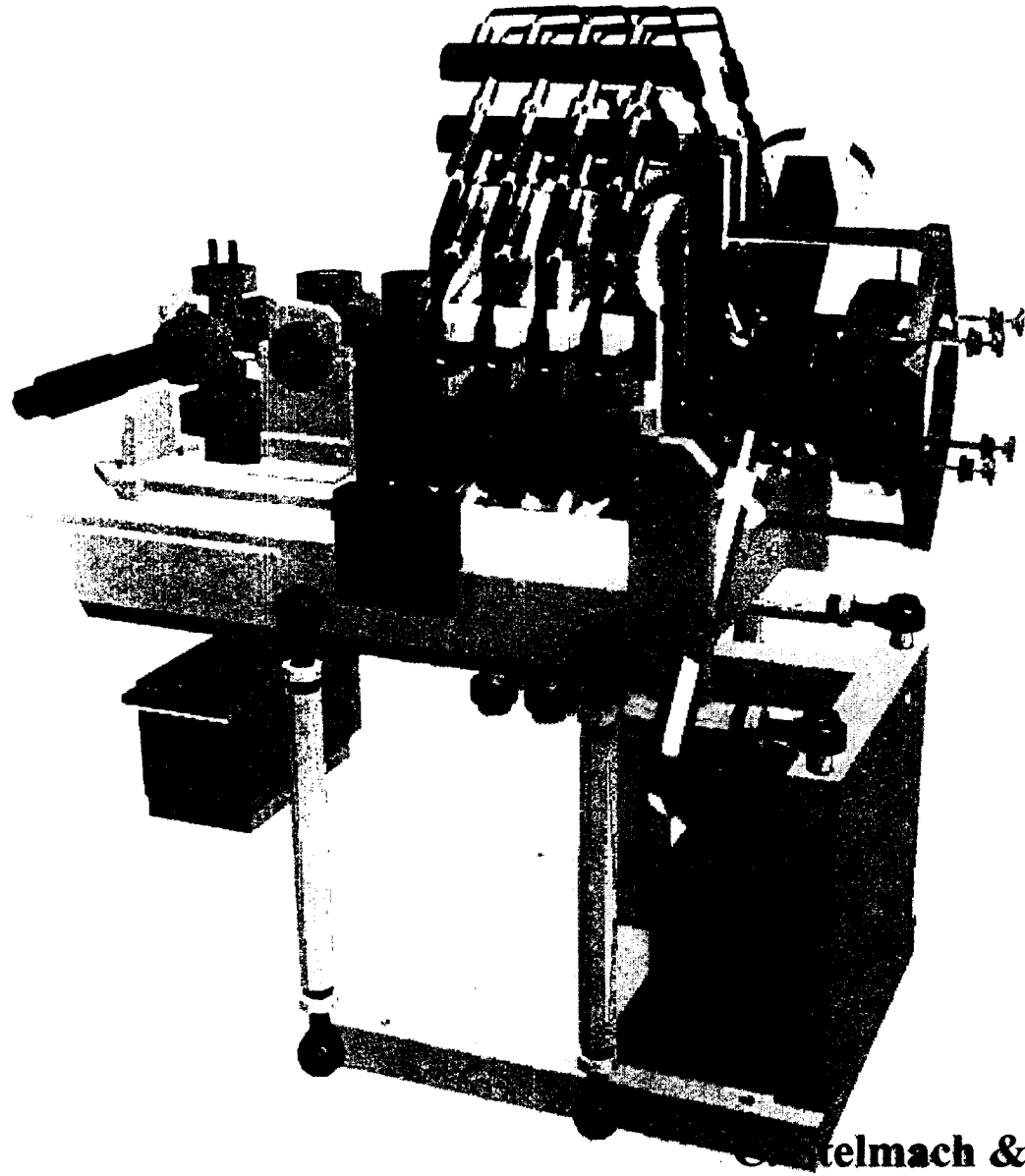
End Station



REV	DESCRIPTION / REV NUMBER	DATE	APPROVED BY	DATE
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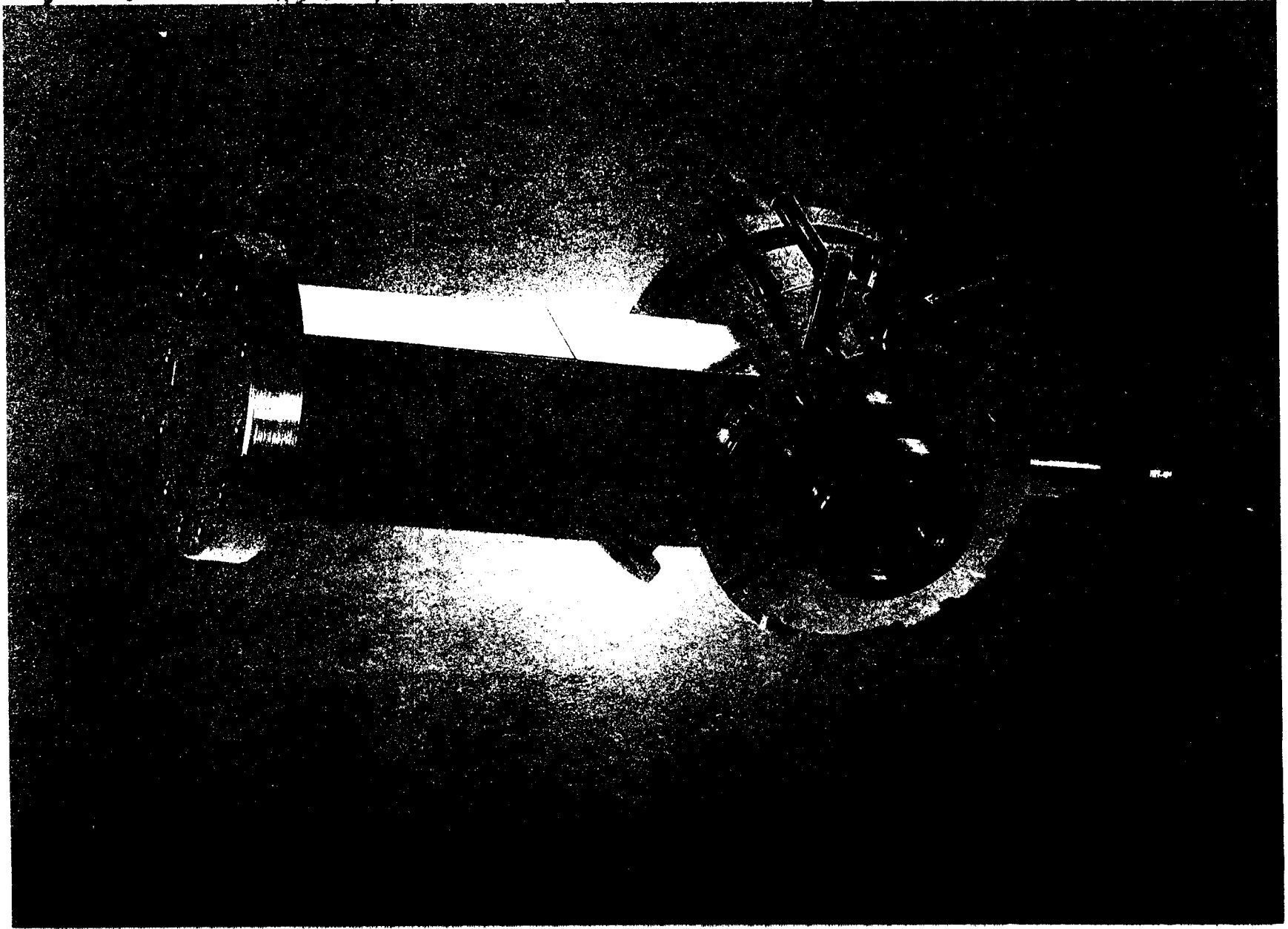
PARTS LIST / BILL OF MATERIALS
 ARMOONK NATIONAL LABORATORY
 ADVANCED PROTON SOURCE
 EXPERIMENTAL MILL
 S10207

BNL Photocathode
RF gun System



Stelmach & S. Pjerov

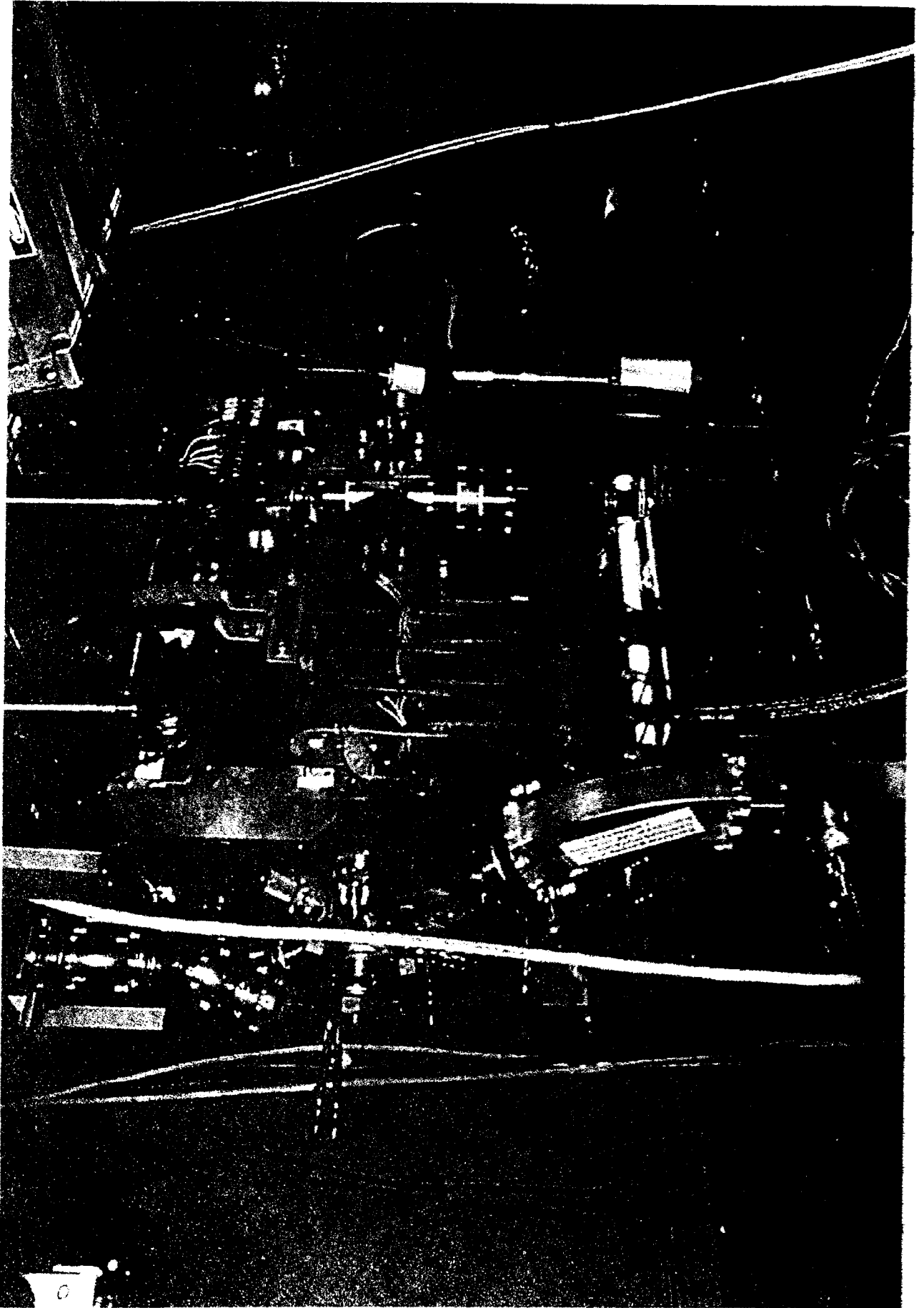
BNL Photocathode RF Gun (Mark IV)



BNL-105-111

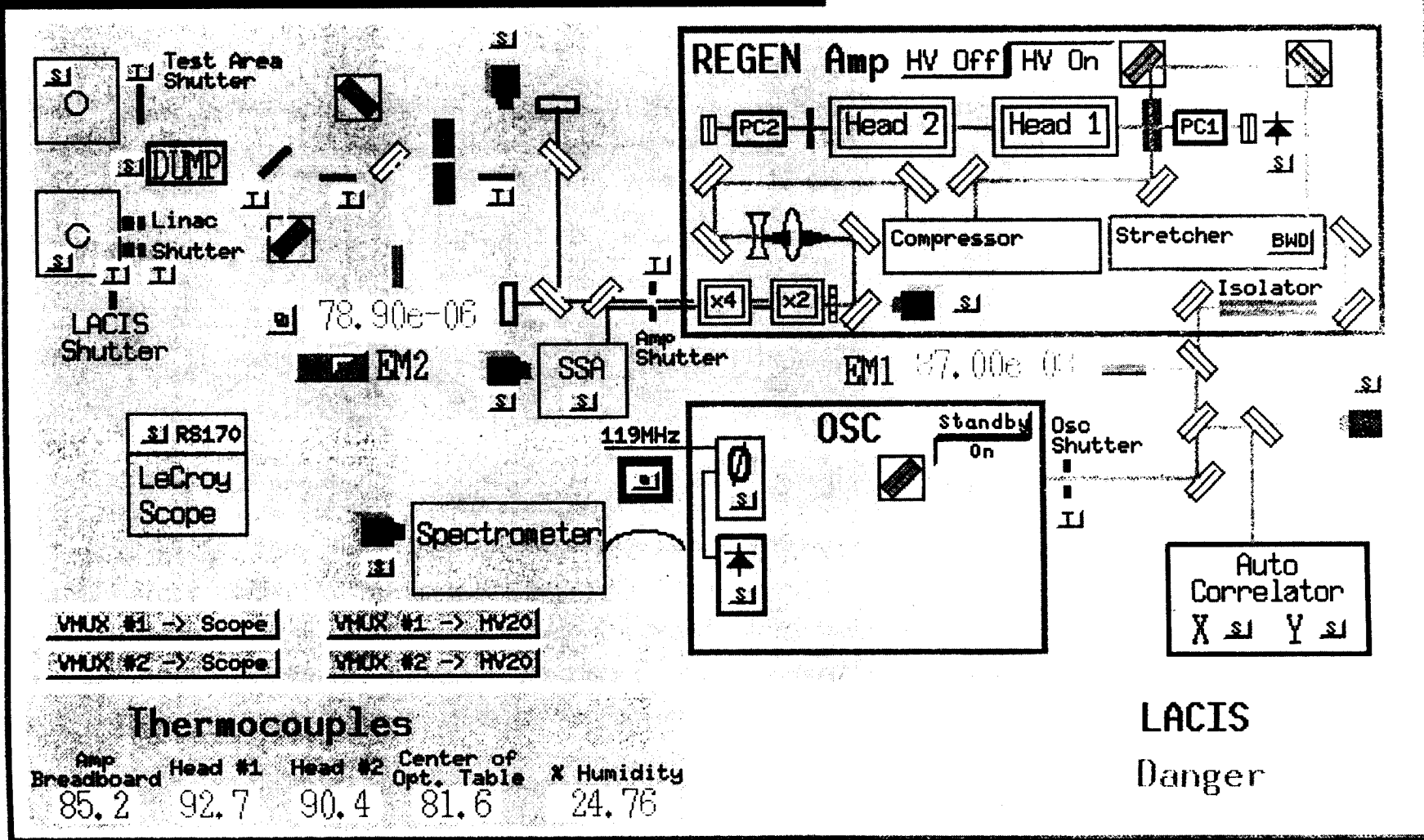
11





LEUTL Drive Laser: System Goals

- Provide light for an S-band, 1.6-cell gun
- Single shot 1 nC, 10 Hz with copper cathode
- Remotely controlled
- Integrated into EPICS control system
- Near "hands off" operation
- High availability (24/7/365)



LEUTL Drive Laser: Measured and Operating Parameters

Oscillator

Wavelength	1053 nm
Pulse Length	200 fs
Avg. Power	~80 mW
Timing Stability	~1/3 ps

Amplifier

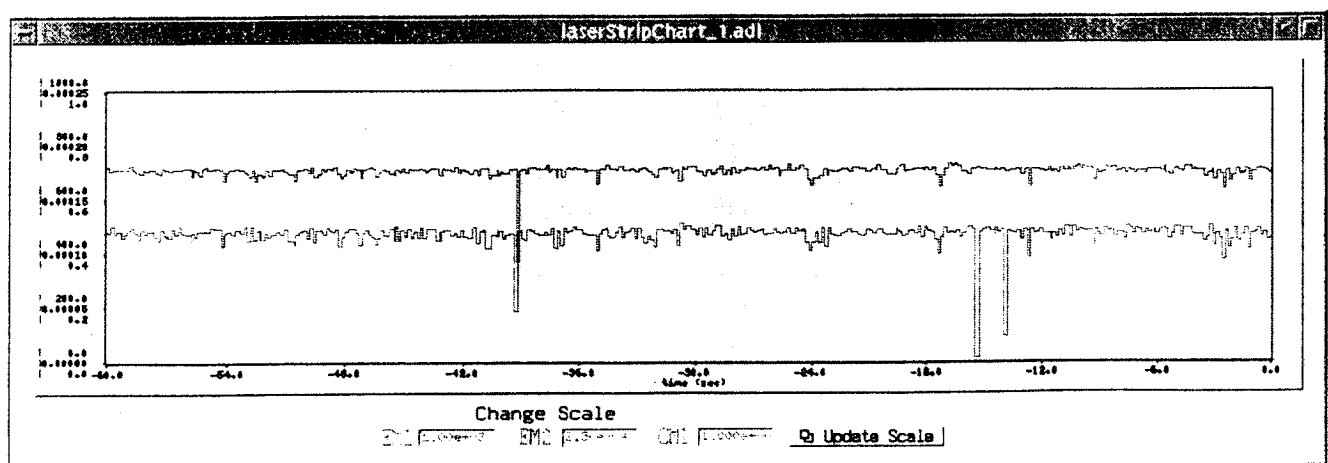
Repetition Rate	6 Hz
Pulse Energy	9 mJ
Lamp Pump Power (x2)	36 J
Shot-to-shot jitter	±5%

Compressor

Efficiency	42%
Output energy	<4 mJ
Pulse length (SSA)	2-6 ps

UV

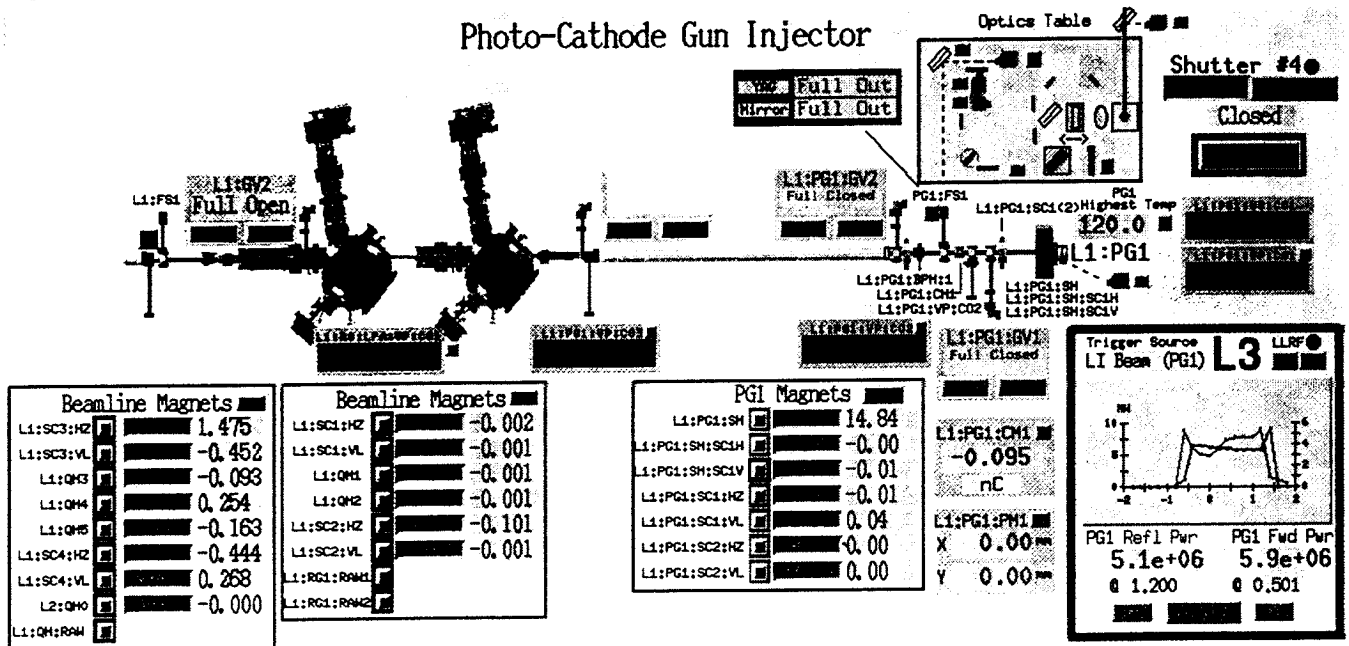
Conversion efficiency	<10%
Energy	<500 μJ
Energy Jitter (saturated)	±5%
Phase Stability (streak)	< 1.5 ps
Pointing jitter @ Cathode	< 0.3 %



Sep 22, 1999

08:10:24

Photo-Cathode Gun Injector

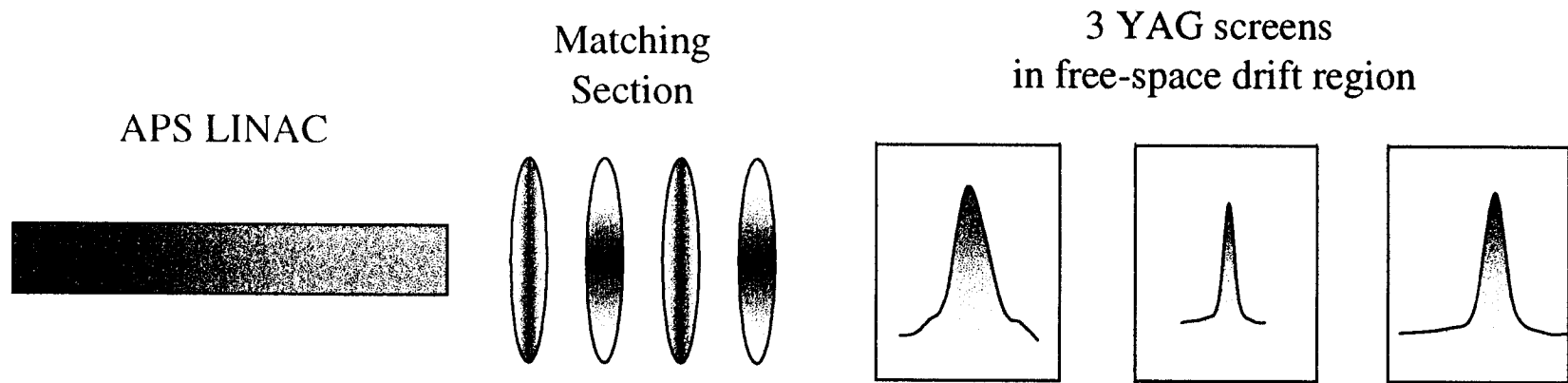


Beam Properties – 530 nm

Beam Property	Required Value*	Measured Value
ϵ_n	5π mm mrad	4 - 6 π mm mrad (x and y planes, averaged)
I_p	150 A	50 - 100 A $\sigma_z = 3 - 6$ ps $Q = 0.3$ nC

* for saturation at 530 nm in 14 m of undulator

3-Screen Beam Property Measurement



Profile measurements
Distance between screens

Beam parameters
 α , β , ϵ

Beamline Geometry
Quad Settings

Settings for “perfect”
match into LEUTL line

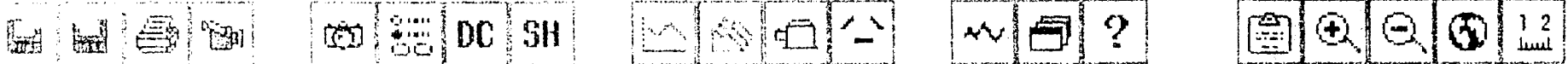
Experimental Background

Streak Camera Measurements

- Optical transition radiation (OTR) converter
- Hamamatsu C5680 mainframe
- Synchroscan, 119.0 MHz
- 220-MeV e-beam energy
- 200-mA macropulse average current
- Data (March 1999)

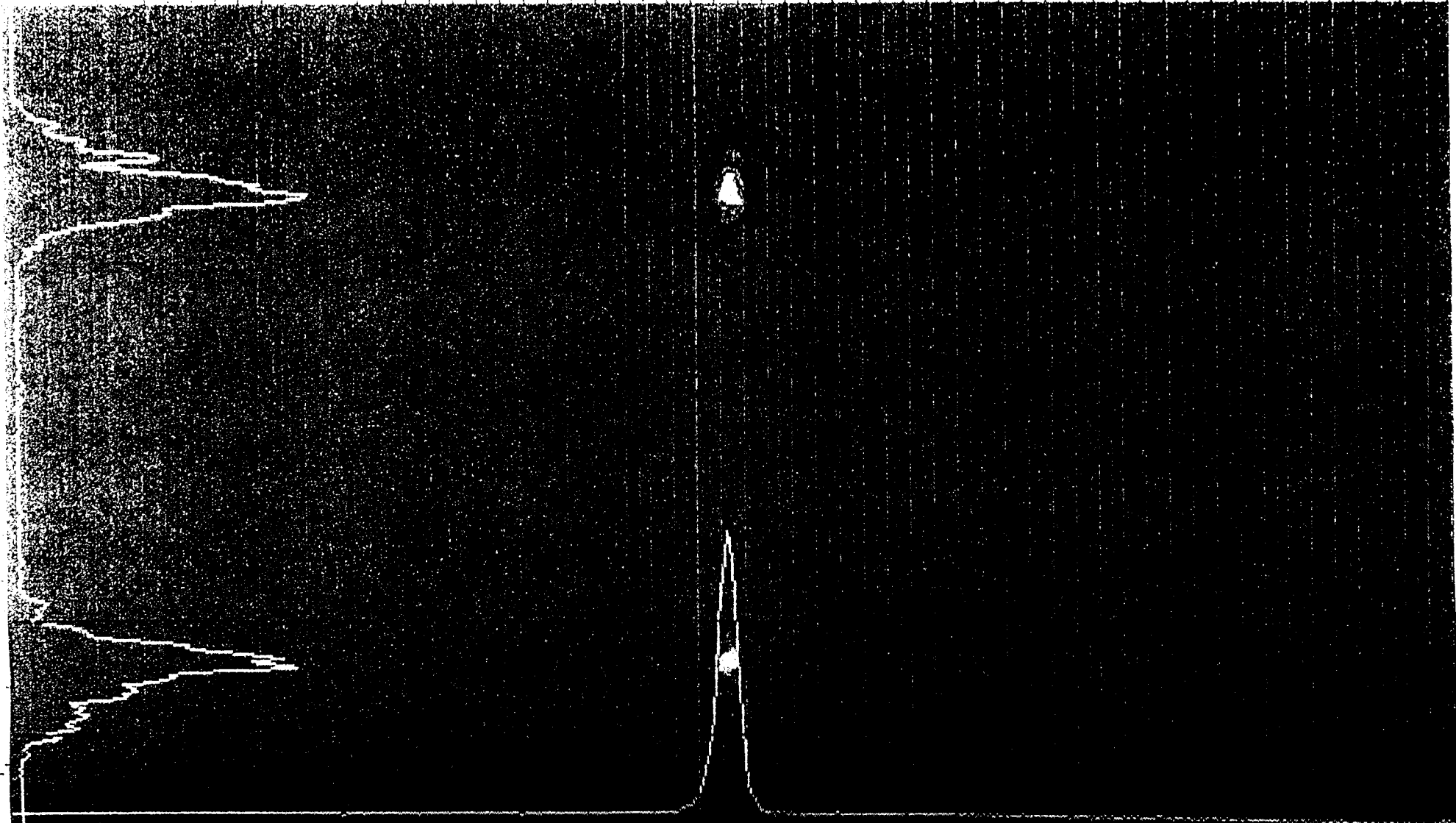
Michelson Interferometer

- Coherent transition radiation (CTR) mechanism
- Novel compact design
- Inconel-coated beamsplitter
- Constructed at Univ. of Georgia under ANL contract
- Golay cell as FIR detector
- 40-MeV e-beam energy
- 200-mA macropulse average current
- Data (May and August 1999)



132599.18 RI OTB 10c Alp146A BP

100ch 200ch 300ch 400ch 500ch 600

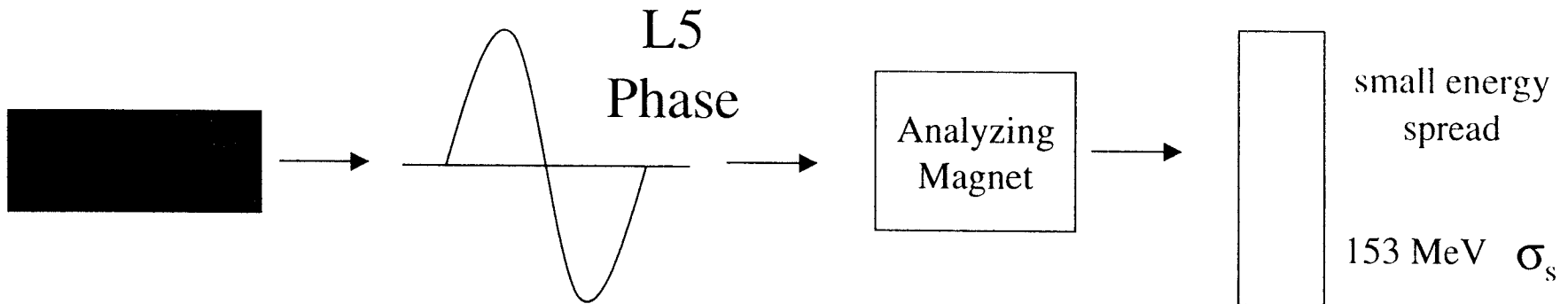
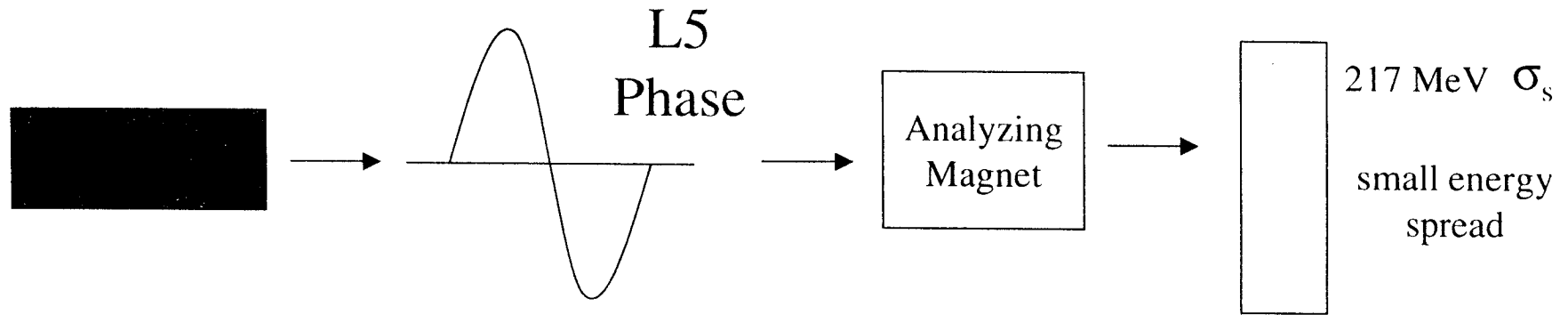


X: 612 Y: 121.437 Peak: 44.82ps ?????cnt
-16 cnt FWHM: 5.463ns

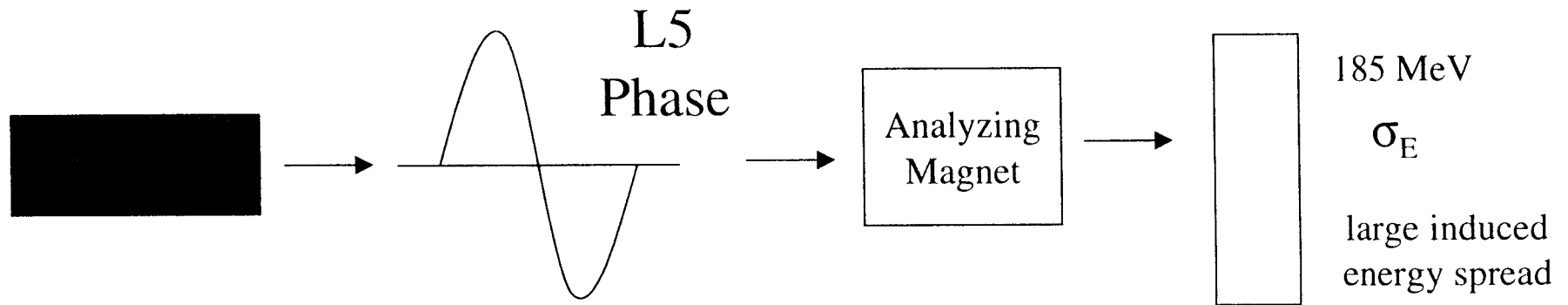


FOCUS HCP Start
n CLOS

Linac-Based Bunch Length Measurements



Linac-Based Bunch Length Measurements



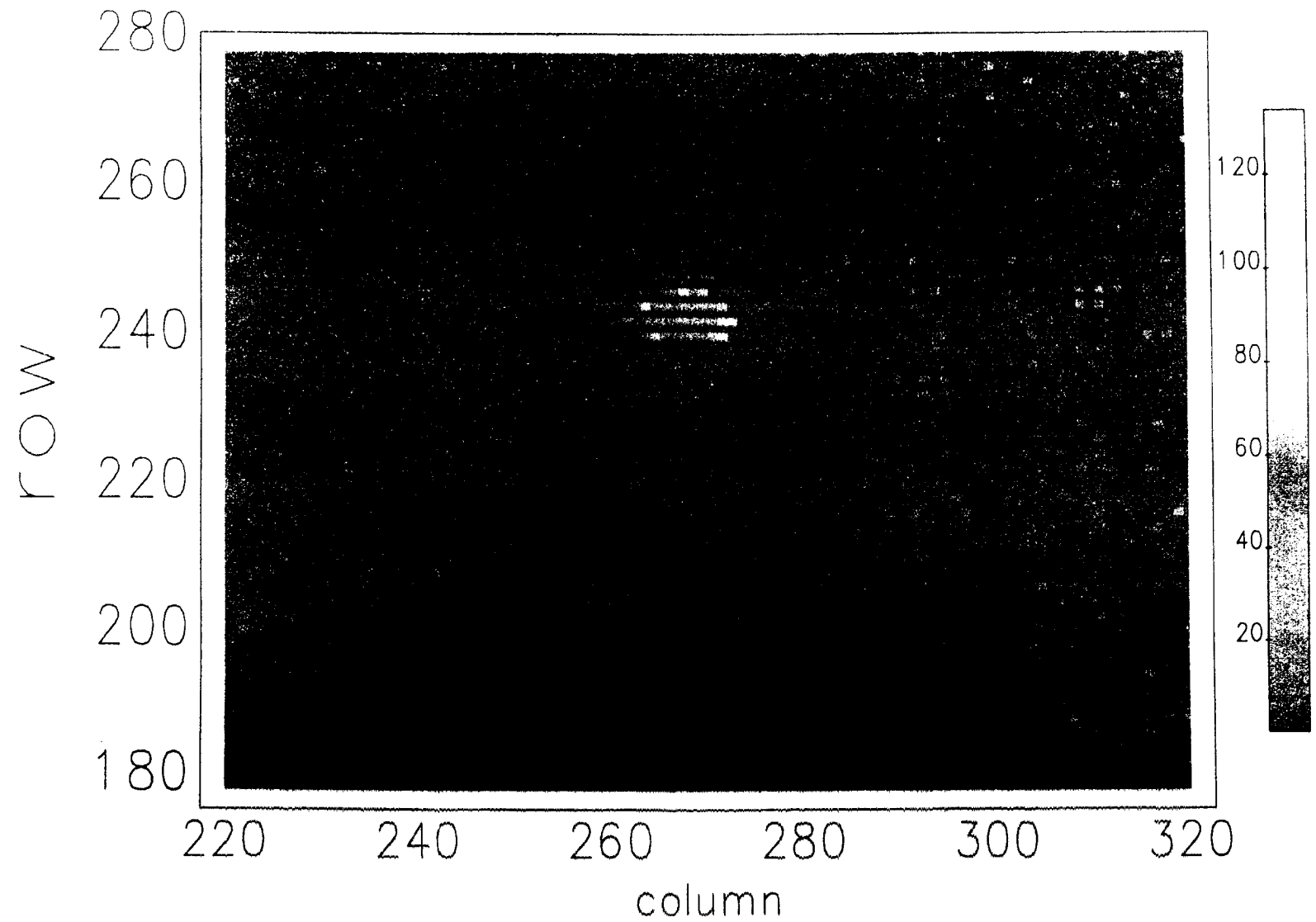
$$\text{Energy gain} = A \sin(\phi)$$

$$\Delta E \sim A \Delta\phi \text{ for small } \phi \text{ (near zero crossing)}$$

$$\sigma_L = \frac{\sqrt{\sigma_E^2 - \sigma_s^2}}{A}$$

On Crest

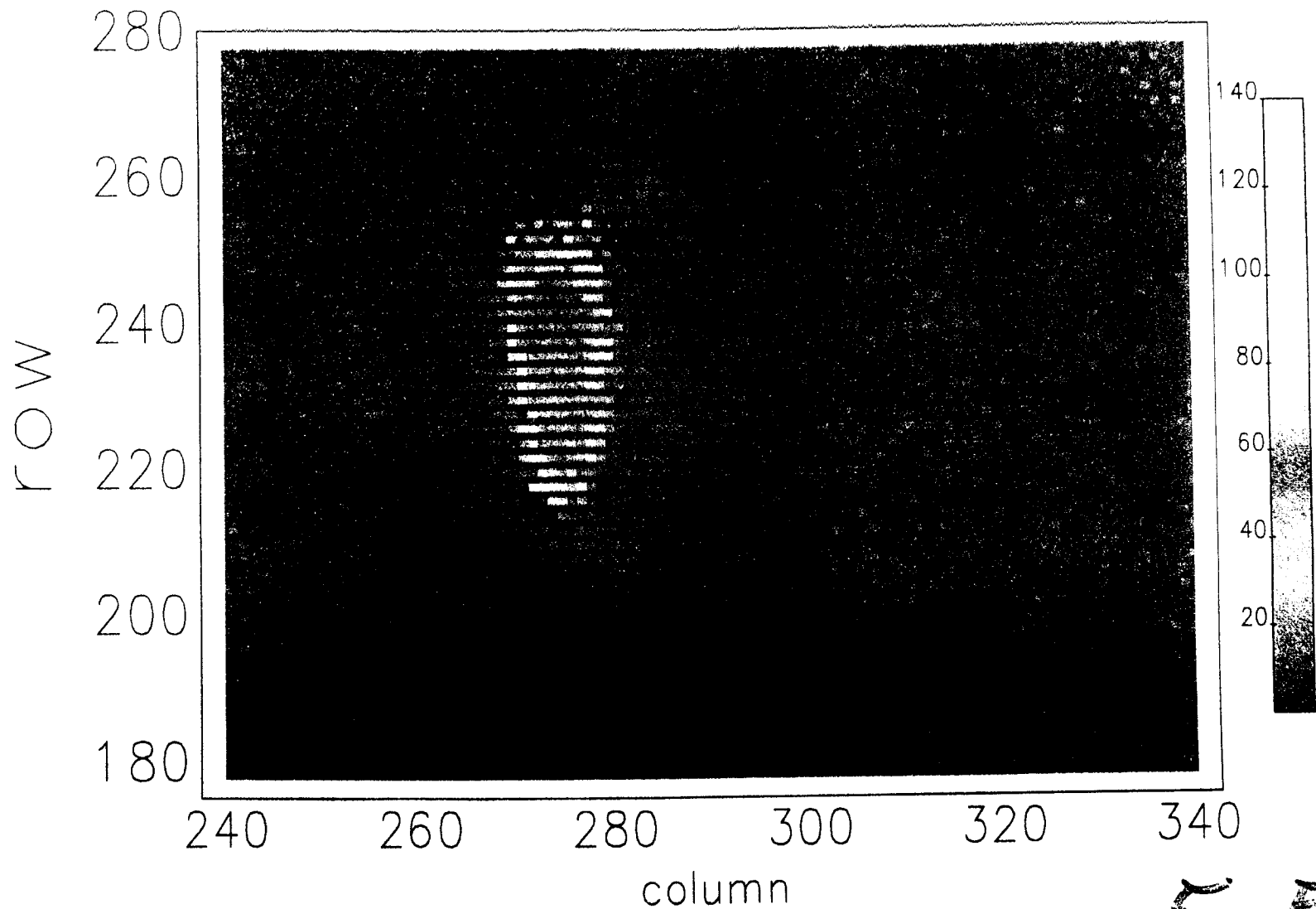
Data from SDDS file /home/helios/LEUTL/daily/9908/08/Screen10NoStreak.sdds, table 1



contours of constant Intensity

"Zero Crossing"

Data from SDDS file Screen10Streaked.sdds, table 1



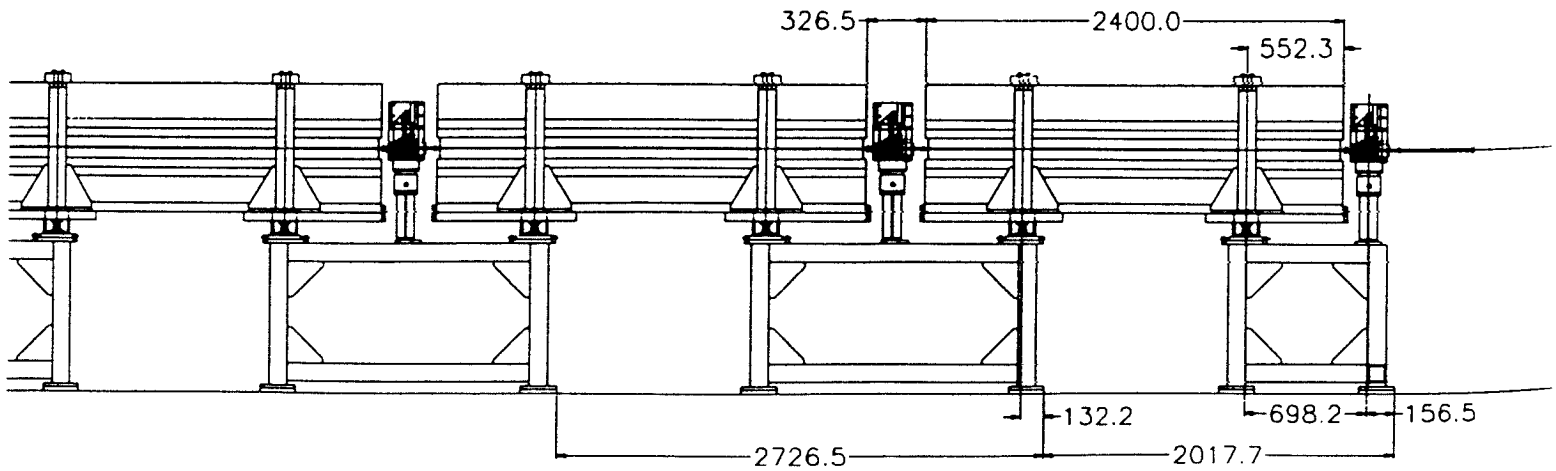
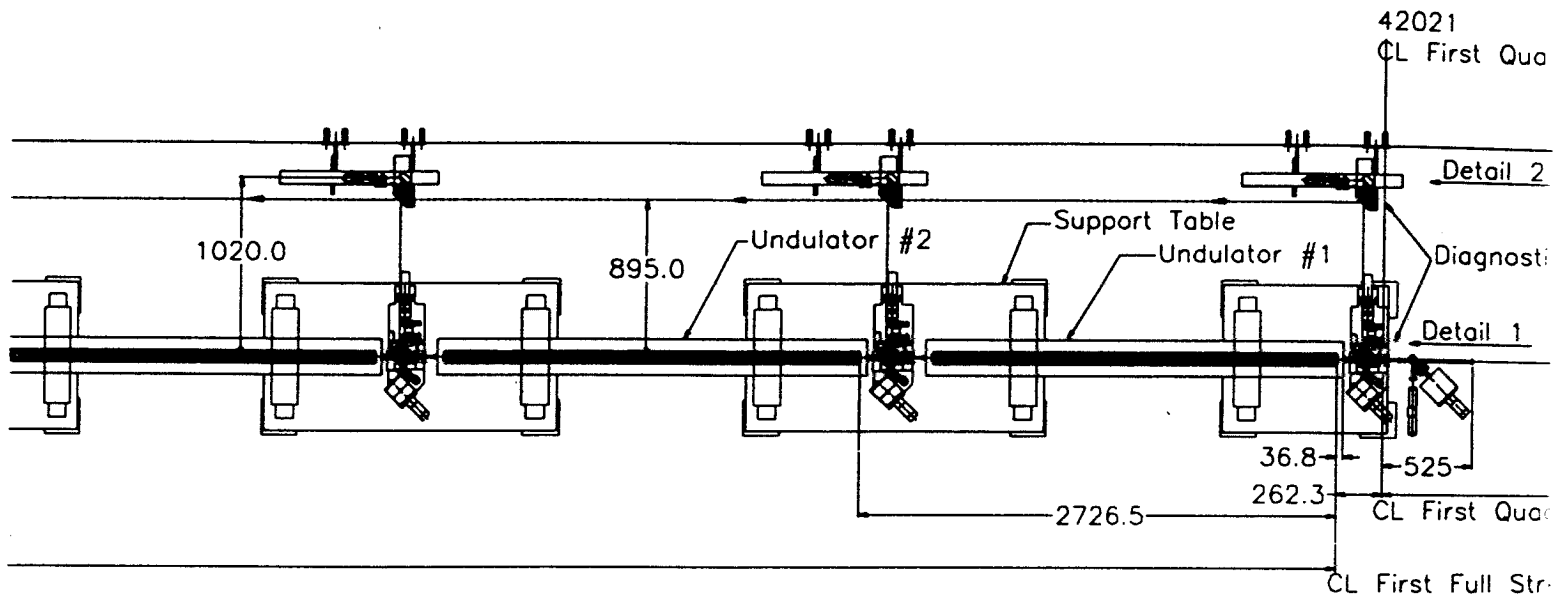
contours of constant Intensity $\approx 5\mu\text{e}$ *FWHM*

Beam Transport Issues

Issue	Causes	Solutions
Linac beam jitter	laser performance	improve power, reduce jitter, clean transverse profile
	rf phase & power jitter	new LLRF system
		rf system cross-comparison to localize jitter sources
	transverse wakefields (amplifying effect)	trajectory studies for wakefield minimization identification of suspected "bad" linac sections

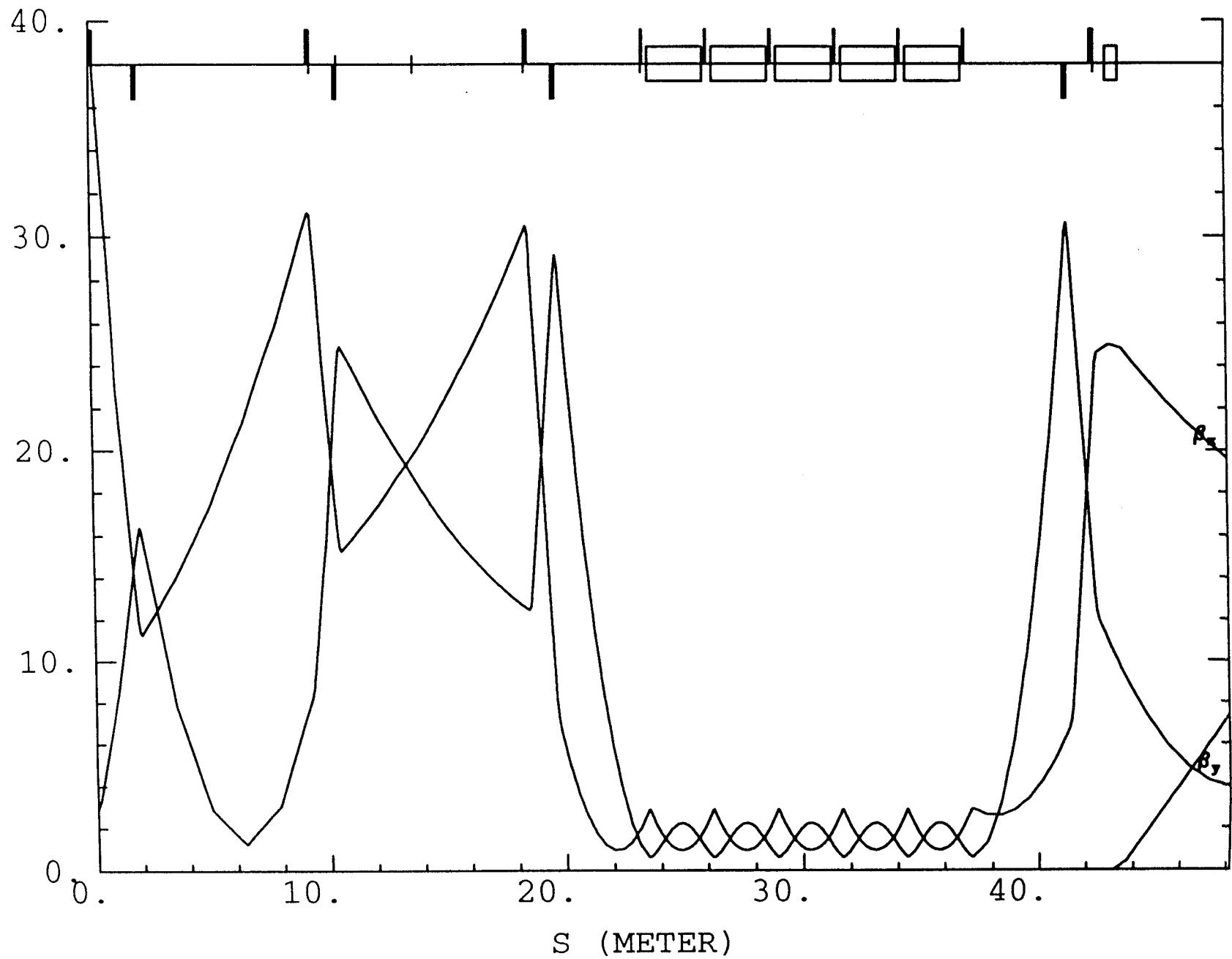
Beam Transport Issues

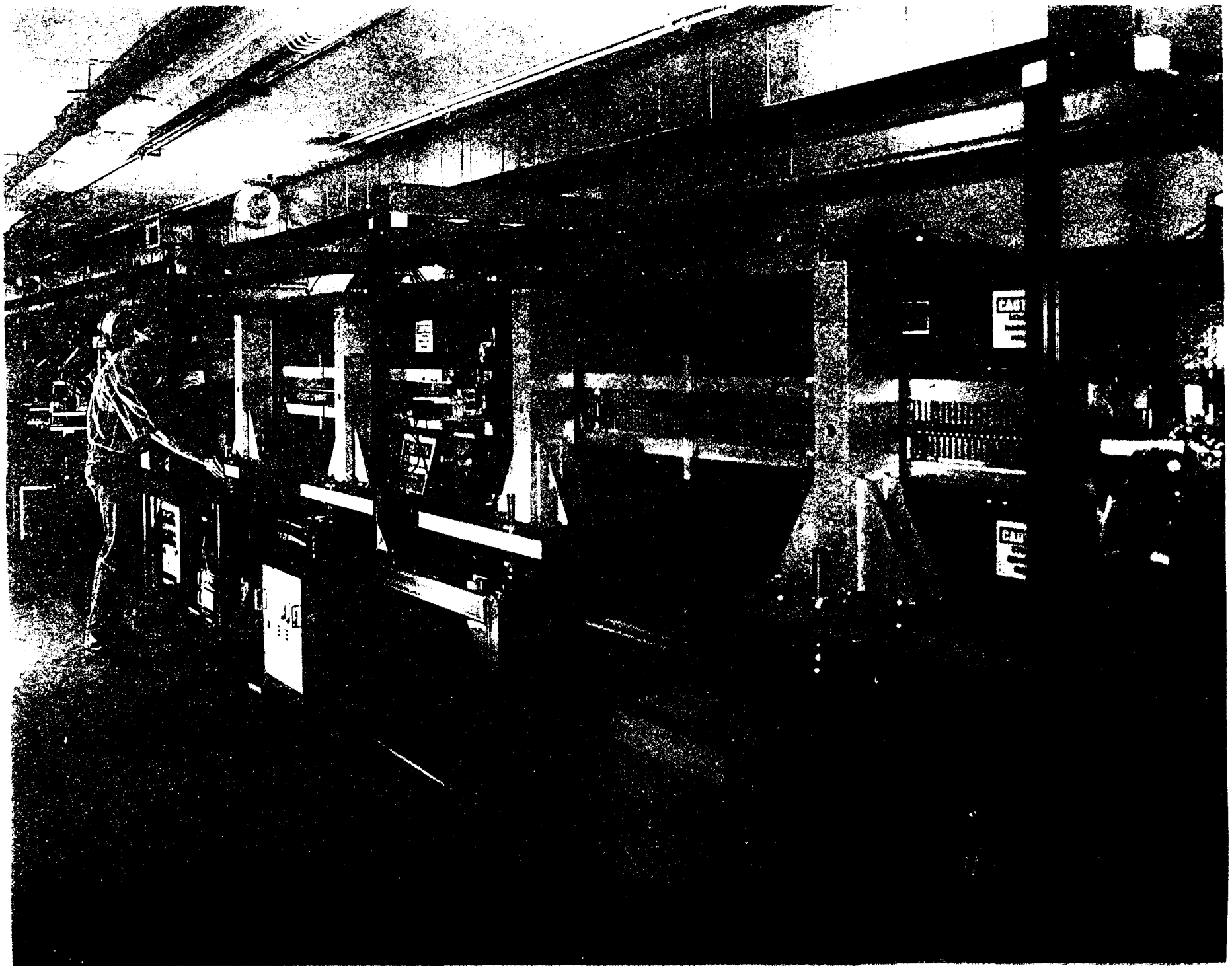
Issue	Causes	Solutions
Transport line mismatch into bypass and undulator lines	off-energy injection into matching section	recalibrate the linac spectrometers
		use BB:BD for spectrometer (higher resolution)
		use undulator light for energy measurement
	“hard” beam parameters at entrance to matching section	search parameter space for better initial conditions
		wakefield reduction



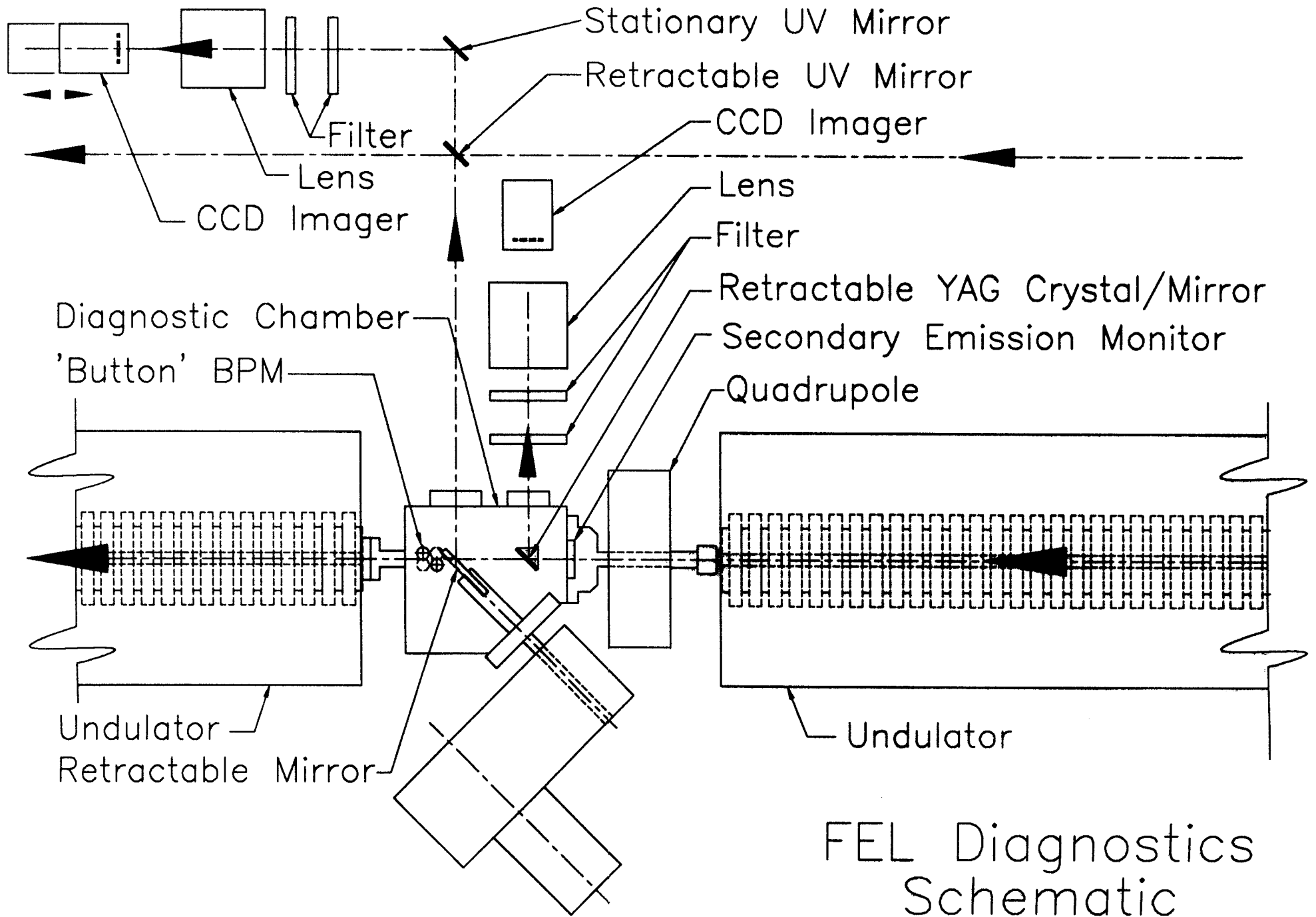
FEL Undulator Assy
 Sketch: Assy-9-16
 C. Benson 9/16/98

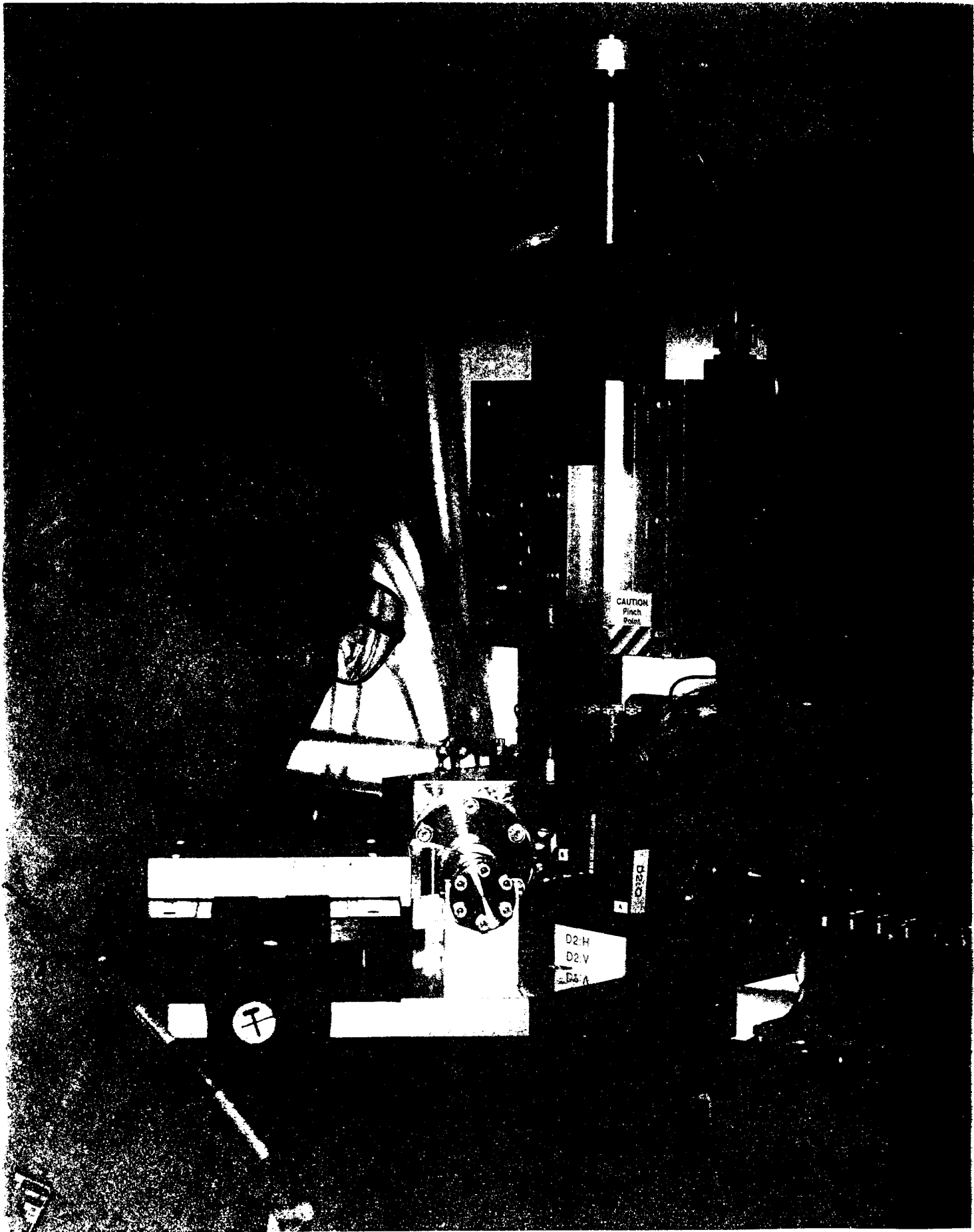
09/17/99 5 UNDULATORS







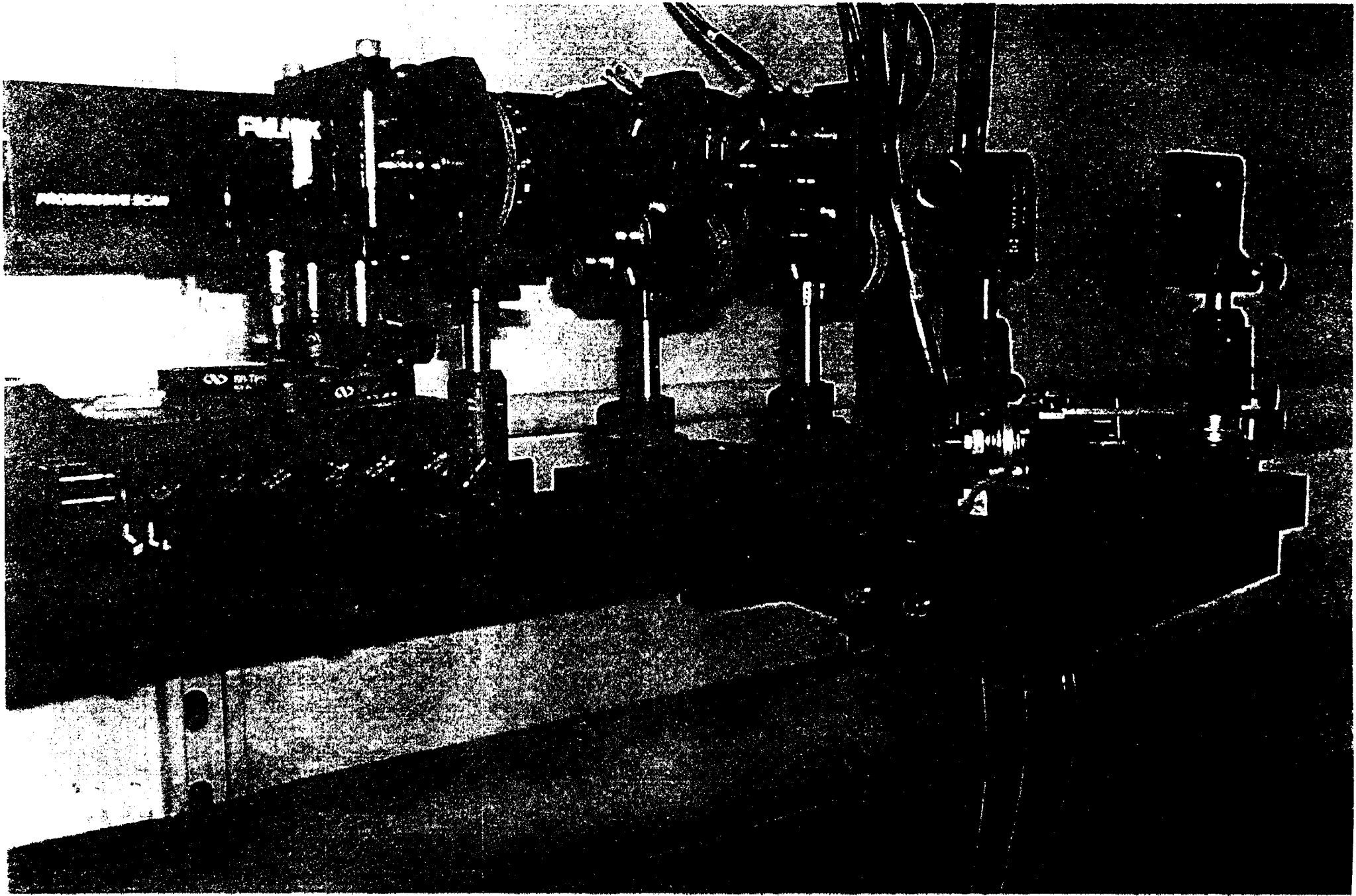




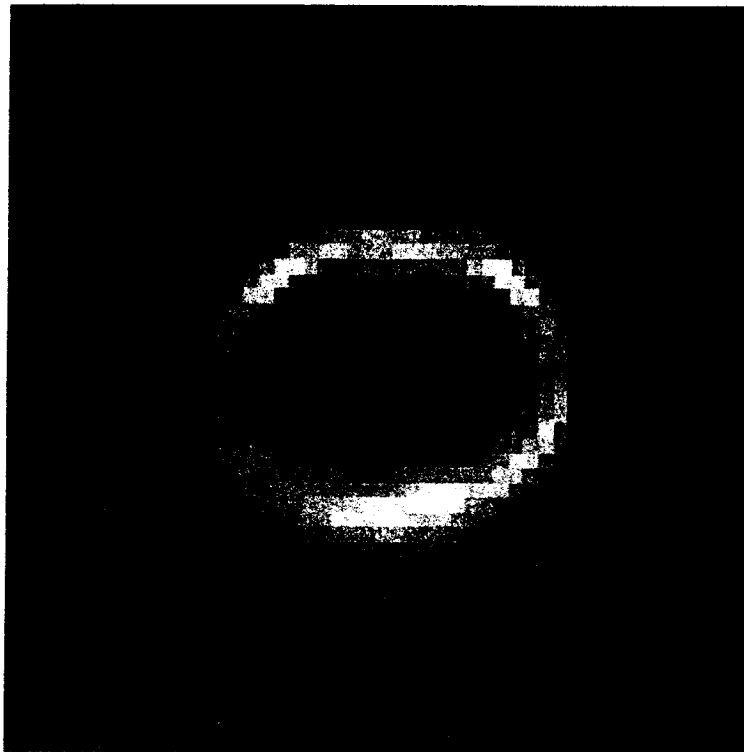
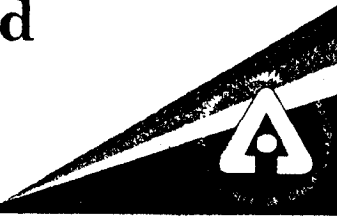
CAUTION
Pinch
Point

D2H
D2V
D2V



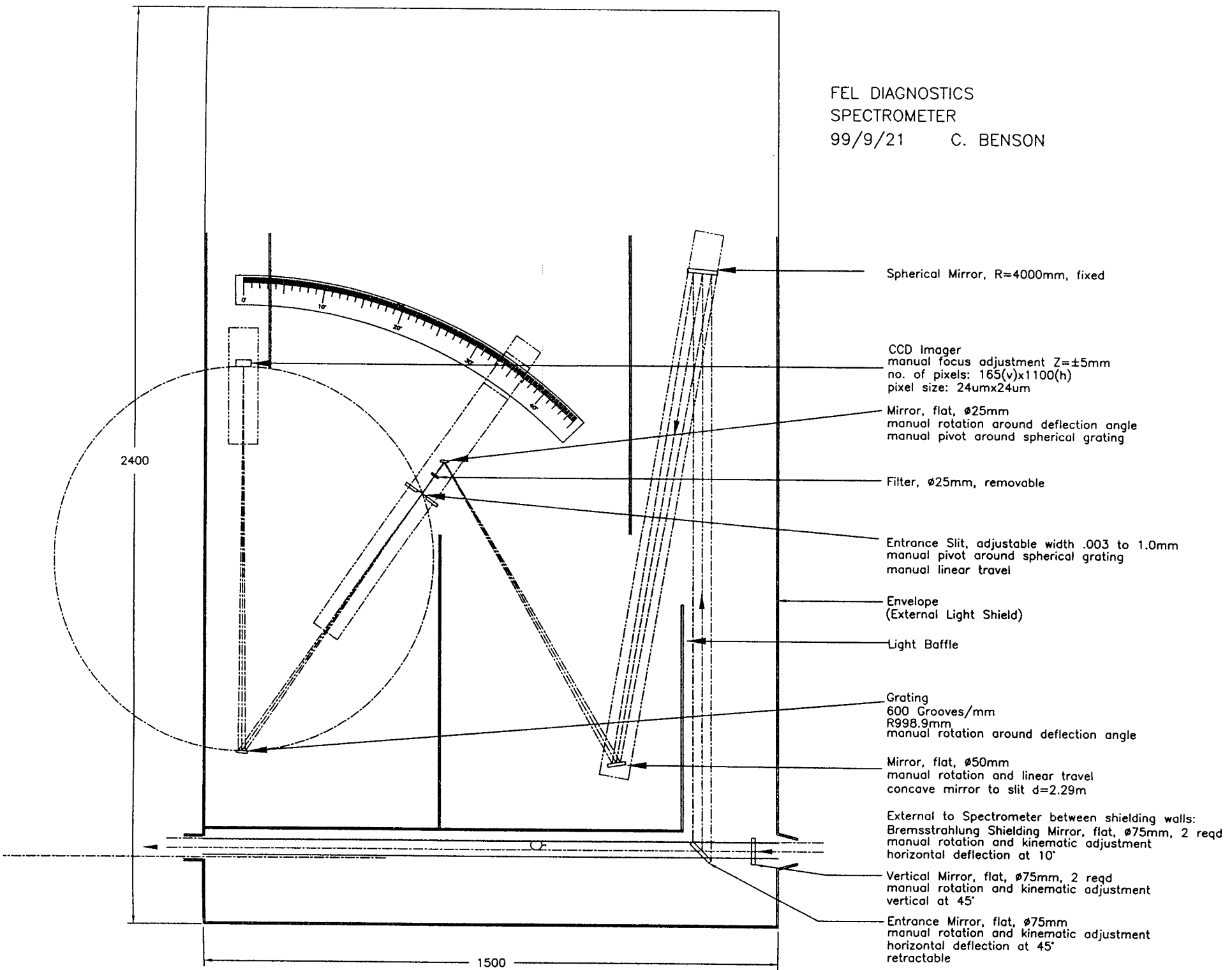


Advanced Photon Source



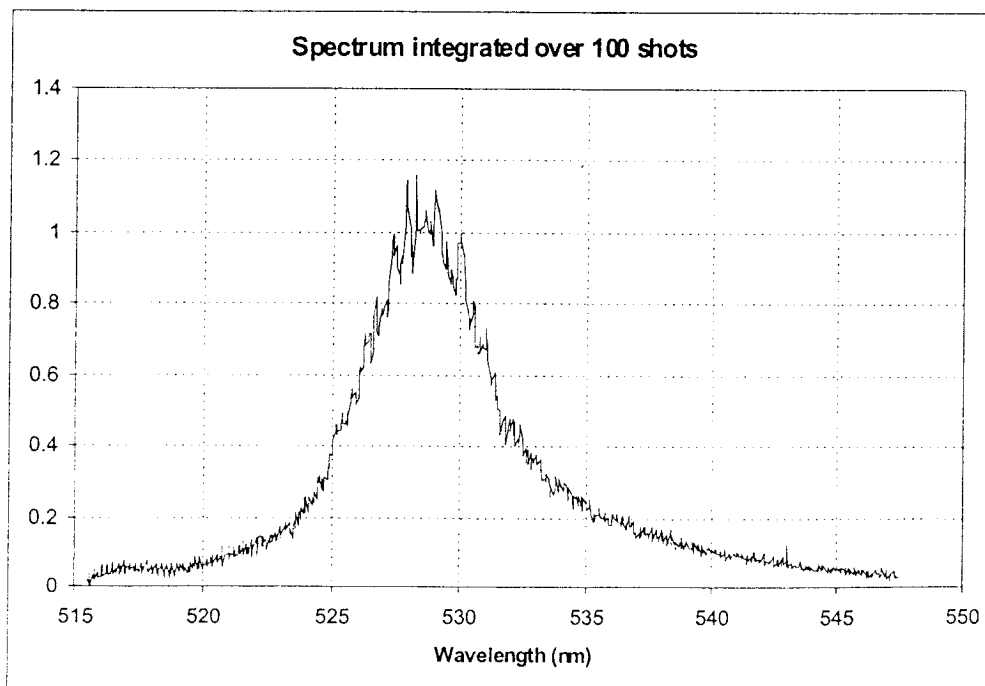
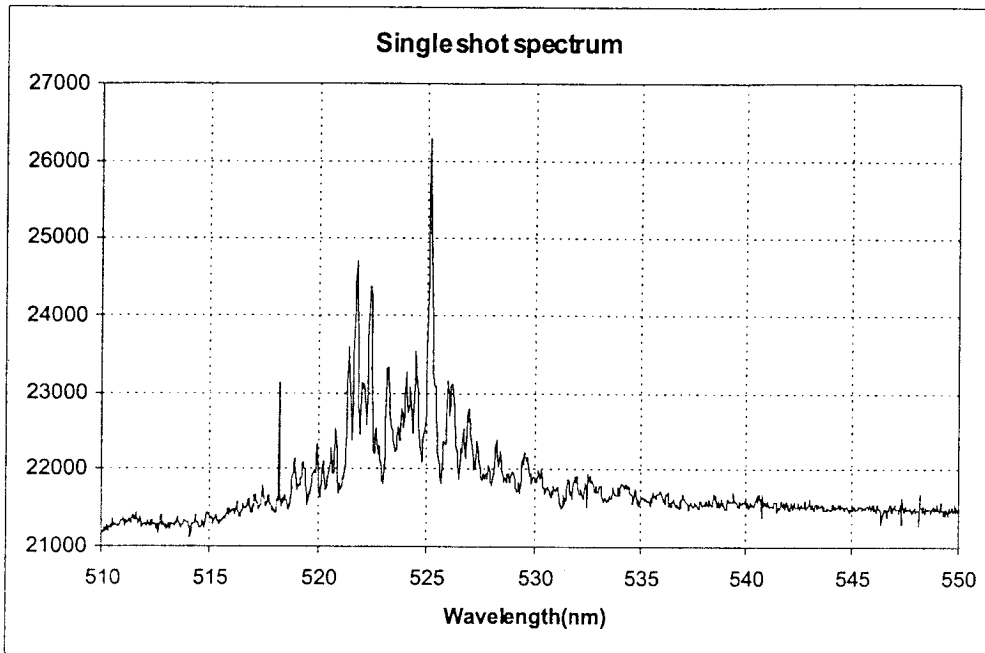
CCD image obtained with.
 $E=217\text{ MeV}$, $\lambda=570\text{ nm}$. The
non-circular aspect ratio is from
the rectangular camera pixels,
 $11.6\ \mu\text{m} \times 13.6\ \mu\text{m}$.

FEL DIAGNOSTICS
 SPECTROMETER
 99/9/21 C. BENSON

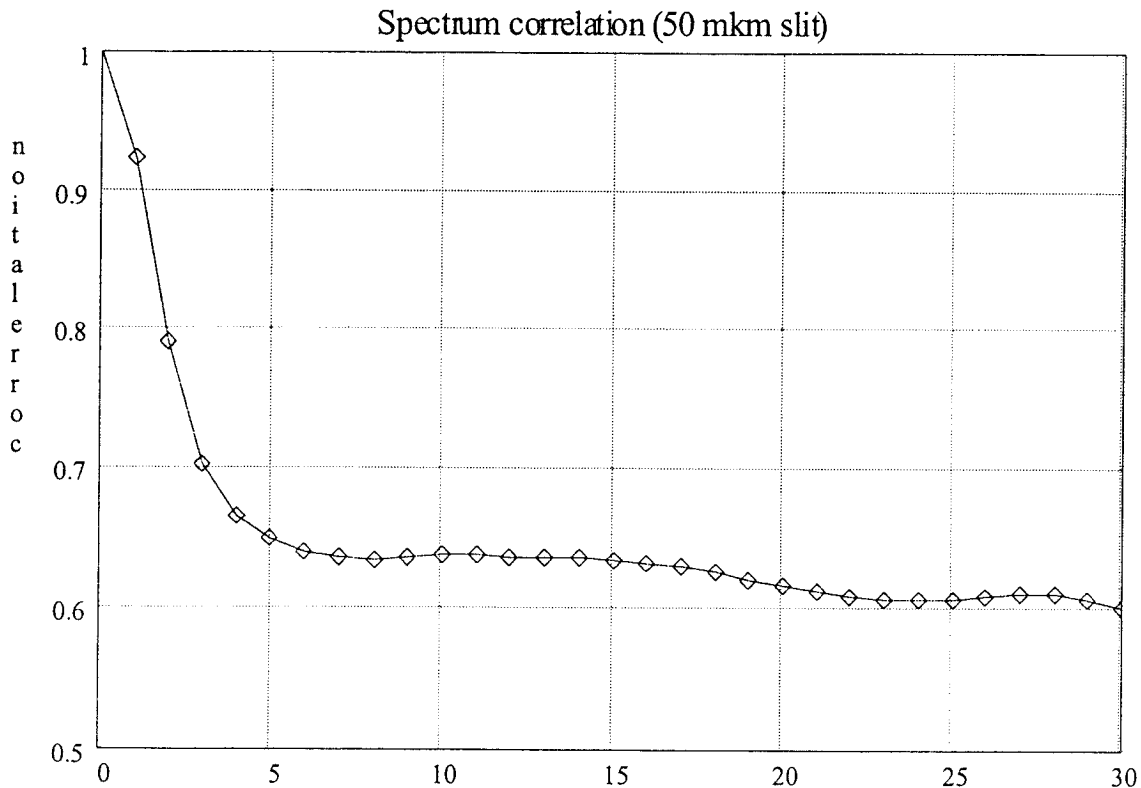


- Spherical Mirror, R=4000mm, fixed
- CCD Imager
 manual focus adjustment $Z = \pm 5\text{mm}$
 no. of pixels: 165(v)x1100(h)
 pixel size: 24 μm x24 μm
- Mirror, flat, $\phi 25\text{mm}$
 manual rotation around deflection angle
 manual pivot around spherical grating
- Filter, $\phi 25\text{mm}$, removable
- Entrance Slit, adjustable width .003 to 1.0mm
 manual pivot around spherical grating
 manual linear travel
- Envelope (External Light Shield)
- Light Baffle
- Grating
 600 Grooves/mm
 R998.9mm
 manual rotation around deflection angle
- Mirror, flat, $\phi 50\text{mm}$
 manual rotation and linear travel
 concave mirror to slit $d = 2.29\text{m}$
- External to Spectrometer between shielding walls:
 Bremsstrahlung Shielding Mirror, flat, $\phi 75\text{mm}$, 2 reqd
 manual rotation and kinematic adjustment
 horizontal deflection at 10°
- Vertical Mirror, flat, $\phi 75\text{mm}$, 2 reqd
 manual rotation and kinematic adjustment
 vertical at 45°
- Entrance Mirror, flat, $\phi 75\text{mm}$
 manual rotation and kinematic adjustment
 horizontal deflection at 45°
 retractable

Advanced Photon Source



Advanced Photon Source



The spectrum correlation was calculated, then averaged over 100 spectra. The bunch length was determined* from the correlation to be 2 ps (1 sigma, assuming a Gaussian).

* method of P. Catravas et al., Phys. Rev. Lett. 82, 5261 (1999)

ADVANCED PHOTON SOURCE

Near-Term Goals

- Installation of Three More Undulators (5 Total)
 - Installation following the October 1999 maintenance period
 - Total length of undulator 12 m
 - Total length of undulator system 13.63 m

- Measurements to Be Made
 - Trajectory and matching verification through undulators
 - Gain measurement at 530 nm
 - Basic measurements of SASE properties
 - ♦ Power vs. Length
 - ♦ Spectral properties
 - ♦ Temporal properties
 - ♦ Fluctuations
 - ♦ Transverse coherence

- Installation of Four More Undulators (9 Total)
 - Ready for installation January 2000
 - Total length of undulator 21.6 m
- Total length of undulator system 24.53 m
 - Full saturation at 530 nm
 - Measurement of harmonics

ADVANCED PHOTON SOURCE

Intermediate Goal

- 380 nm (265 nm) Operation to Saturation
 - Requirements
 - ♦ $E = 256 \text{ MeV}$ (307 MeV)
 - ♦ $I_{peak} = 100 \text{ A}$
 - ♦ $\varepsilon\gamma = 4 \pi \text{ mm-mrad}$
 - ♦ $\delta = 0.01\%$
 - ♦ $L_{und} = 18.1 \text{ m}$ (21.7 m) (Undulator/Saturation Length)
 - Does not require vacuum transport of light

- Schedule
 - Summer 2000

ADVANCED PHOTON SOURCE

Long-Term Goals

- Additional Undulators
 - Have room for up to 13 undulator cells
 - ♦ 31.2 m of undulator
 - ♦ 35.4 m total length of undulator system
 - Buncher/Radiator Operation

- Operation to Saturation at 120 nm
 - Requires vacuum transport system
 - Experimental (user) group already expressing interest
 - Earliest date envisioned to start: January 2001

- Reduce Wavelength to Limit of Linac Energy
 - 70 nm (600 MeV) -> 50 nm (700 MeV) range possible

- Parallel Beamline
 - LEUTL tunnel capable of supporting a second parallel beamline
 - Could attempt fast switching experiments envisioned for 4th generation light sources

Bunch Compressor Overview: Project Description

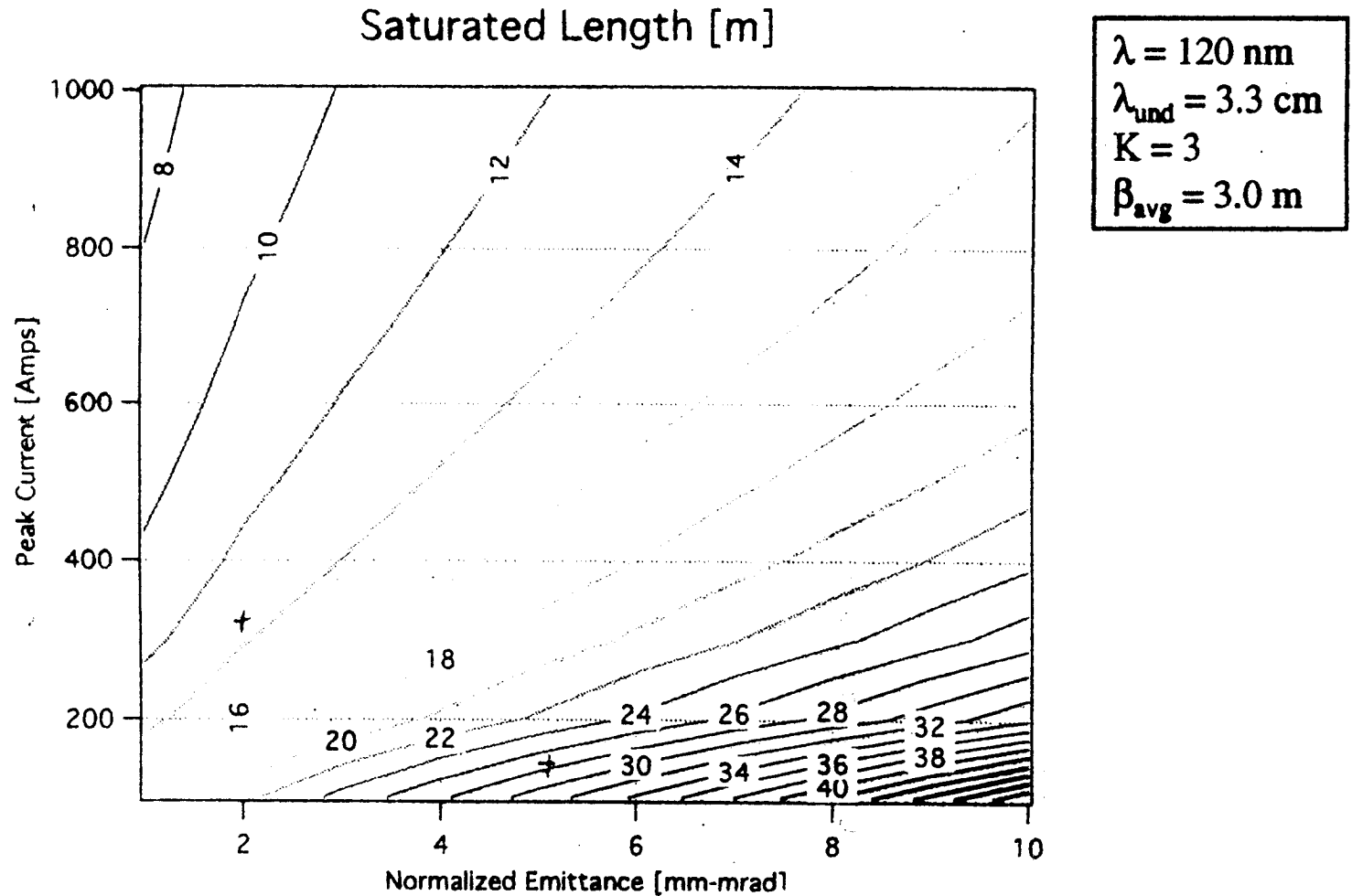
- Primary objective and motivation
 - Improve the performance, i.e., "brightness" of the electron beam in order to reduce the length of undulator needed to reach saturation in a single pass FEL

- Requires
 - Induced correlated energy spread on the bunch
 - Controlled dispersion bump
 - Diagnostics

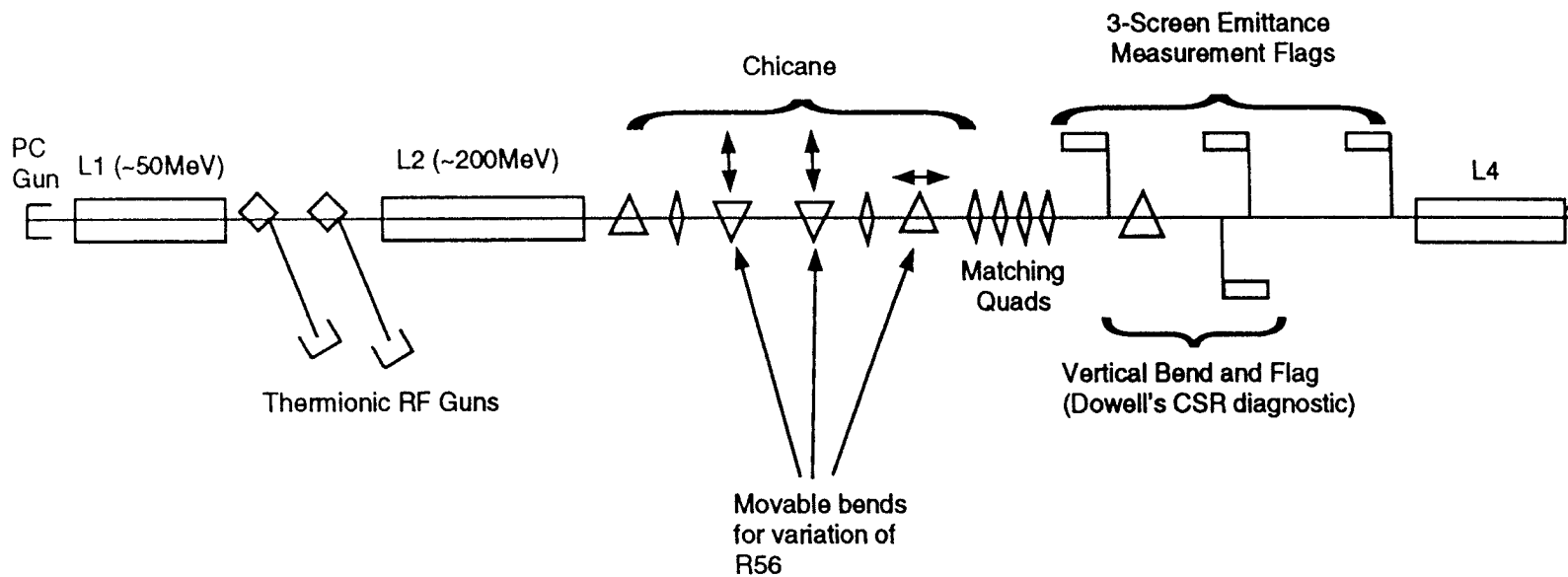
- To be installed into the APS linac
 - The design **MUST** be compatible with APS operations

- Secondary objectives
 - To study the coherent synchrotron radiation (CSR)
 - To build a bunch compression system similar enough to that planned for the LCLS that the results could be used to improve the LCLS bunch compressor 1 (BC1) base design

SASE FEL Performance



Schematic of the APS Linac and Proposed Bunch Compressor



Addition of CSR to elegant

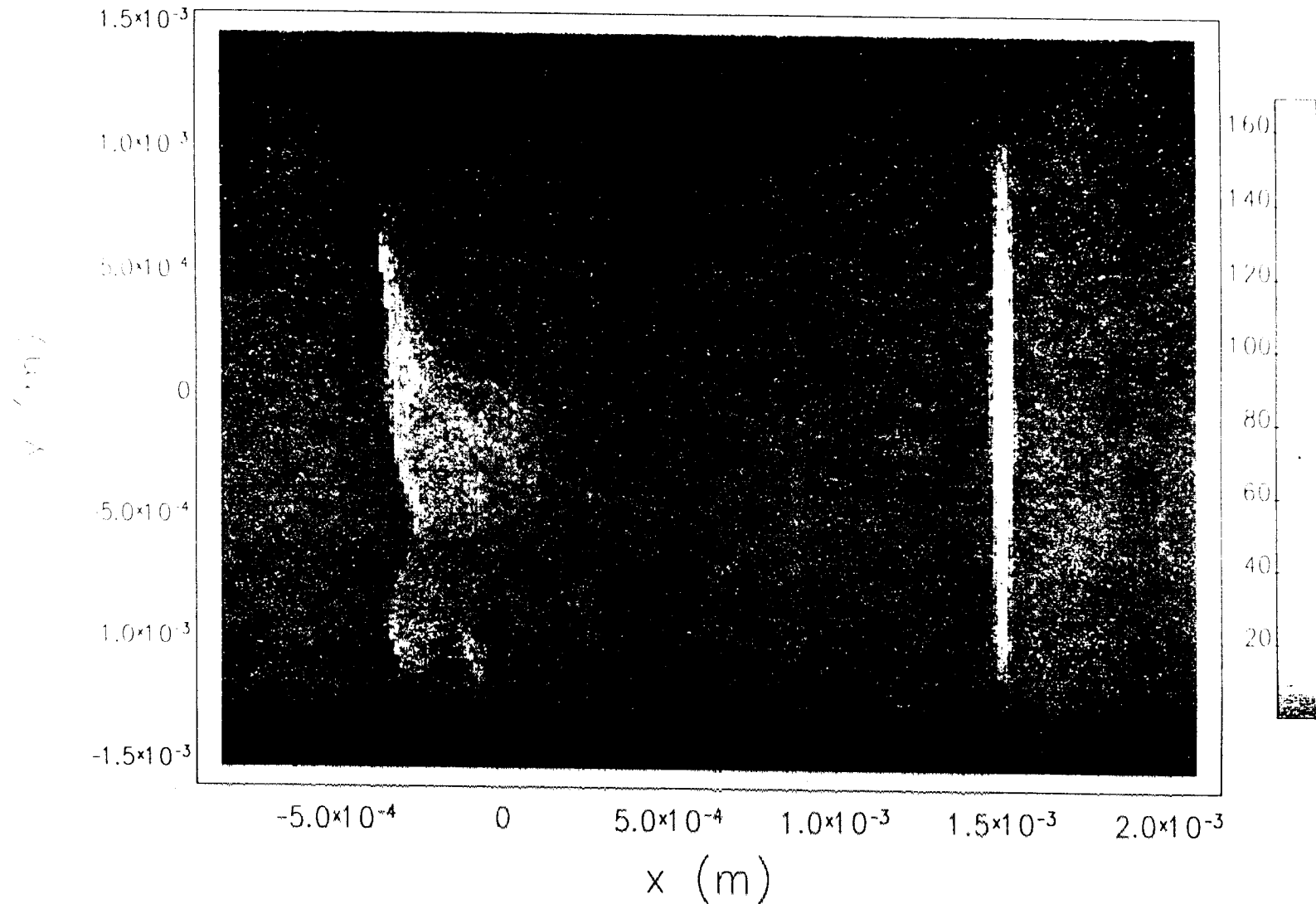
- Based on the work of E. L. Saldin, *et. al.*, in NIM A 398 (1997). They give,

$$\frac{dE(s, \phi)}{cdt} = \frac{-2e^2}{3^{1/3}R^{2/3}} \left\{ \left(\frac{24}{R\phi^3} \right)^{1/3} [\lambda(s-s_L) - \lambda(s-4s_L)] + \int_{(s-s_L)}^s \frac{1}{(s-z)^{1/3}} \lambda(z)' dz \right\}$$

where R is bend radius, ϕ is the angle into the bend, $s = ct$, s_L is the slippage length, and $\lambda(s)$ is the linear density of the bunch.

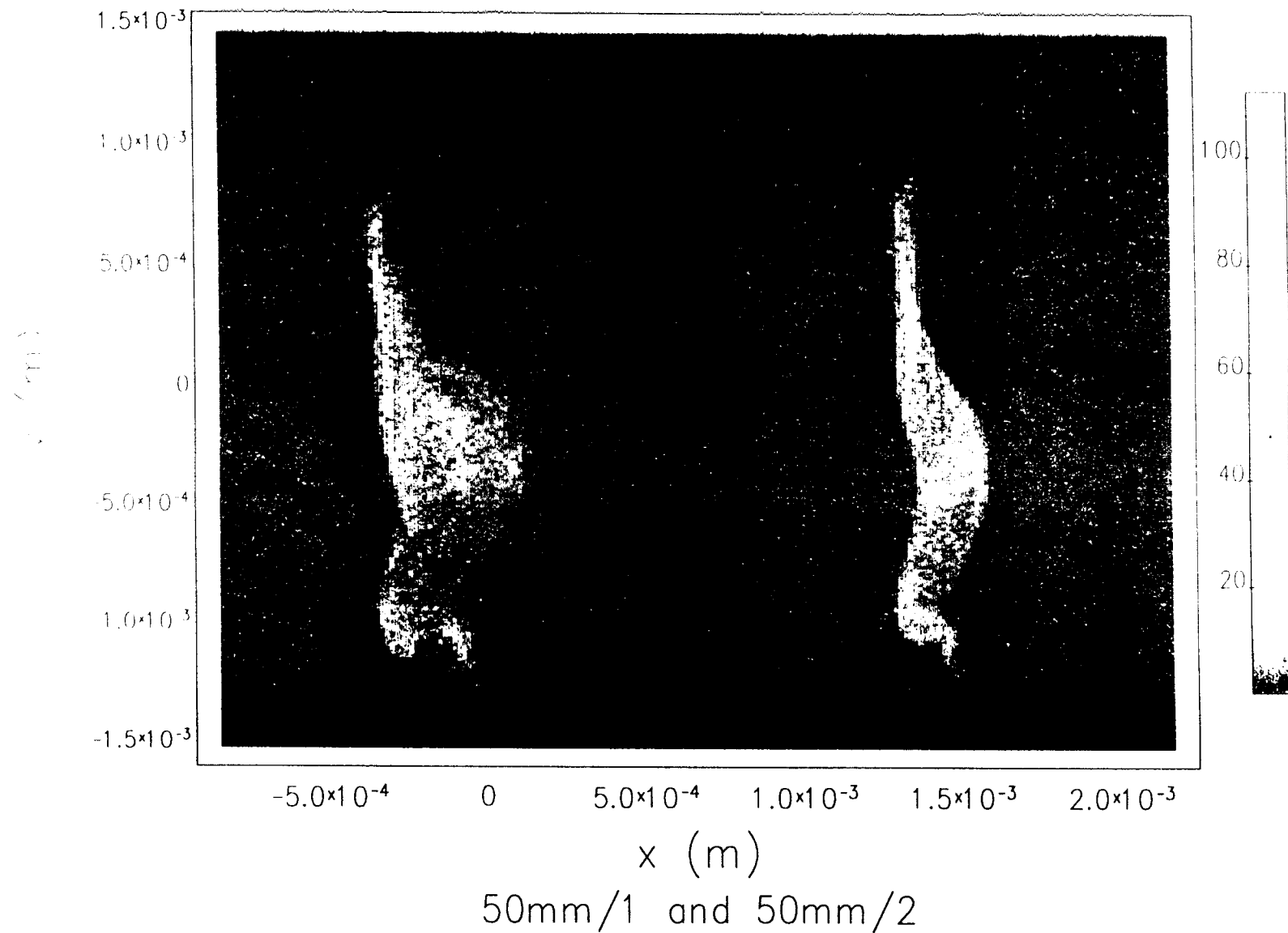
- Algorithm:
 - The dipole is divided into a user-specified number of pieces. 60 is adequate but 100 is better.
 - For each piece, a fourth-order canonical integration is done for the dipole fields.
 - Following this, the CSR energy kicks are applied.

Dowell's CSR diagnostic simulation



CSR on/off for 50mm/1 case

Dowell's CSR diagnostic simulation



ADVANCED PHOTON SOURCE

Very Long-Term Goals

- Linac Energy Upgrade
 - Motivation
 - ♦ To push to the "water window" (~ 4 nm -> 2 nm)

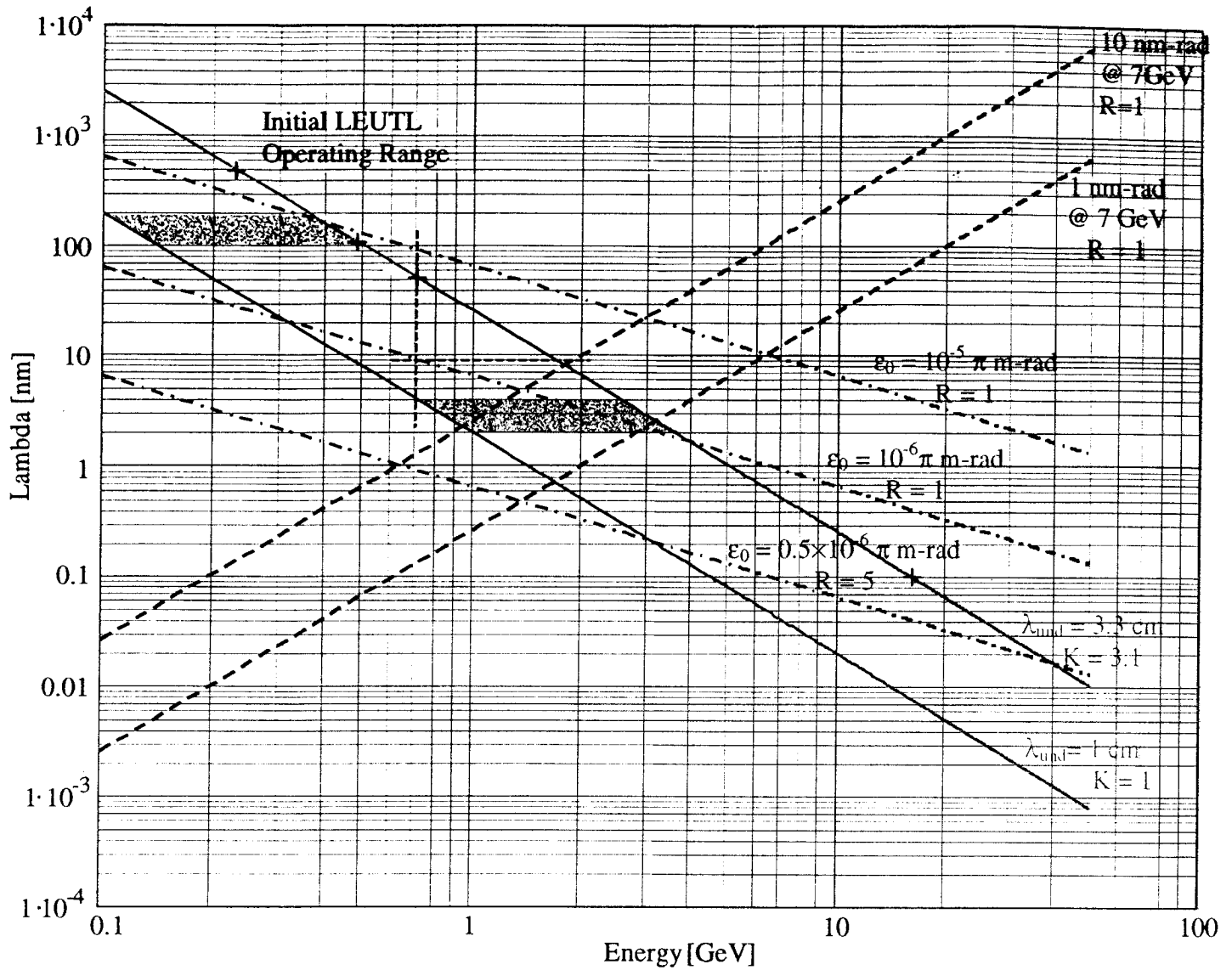
ADVANCED PHOTON SOURCE

	Energy [MeV]						
	217		457		1000		
Beam Parameters							
emit [pi mm-mrad]	5	5		3		1.5	1.5
Ipeak [A]	150	150		300		800	800
delE/E [%]	0.1	0.1	0.1	0.1		0.05	0.05
Undulator Parameters							
LambdaU [cm]	3.3	3.3	3.3	3.3	3.3		
K	3.1	3.1	3.1	3.1	3.1		
FEL Output							
Lambda [nm]	530	120	120	51	25	3	3
Lgain [m]	0.64	1.6	0.72	1.2	0.73	1.4	1.5
Lsat [m]	13.8	31	15	24	15.3	27	28
Ppeak [MW]	73	41	270	200	1980	230	560
Brightness [x10 ²⁸]	1.4	4	20	37	263	60	278

Items in ██████ are changes made.

Items in yellow are some significant results of the changes made.

Advanced Photon Source



Undulator Resonant Condition:

$$\lambda_L = \frac{\lambda_{und}}{2\gamma^2} \left(1 + \frac{K^2}{2} \right)$$

Diffraction Limit Requirement:

$$\lambda_L > \lambda_{diff} = \frac{4\pi\epsilon}{R}$$

Linac Emittance Scaling:

$$\epsilon = \frac{\epsilon_0}{\gamma}$$

$$\gamma = \frac{E}{m_e c^2}$$

Storage Ring Emittance Scaling:

$$\epsilon \propto \gamma^2$$